



Large-Scale Terahertz Active Arrays in Silicon Using Highly-Versatile Electromagnetic Structures

(Invited Paper)


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The Dawn of a New Terahertz Era

Applications (Demos)




CO 1.5 THz



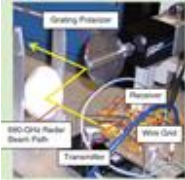

Today

This section illustrates current applications and demonstrations of terahertz technology. It features an astronomical image labeled 'CO 1.5 THz', a medical scan of a human torso with a red circle highlighting a specific area, and a photograph of a white terahertz antenna mounted on a black tripod. A large red arrow labeled 'Today' points from these applications towards the enabling technology section below.



Enabling Technology



Top waveguide
Substrate
Bottom contact

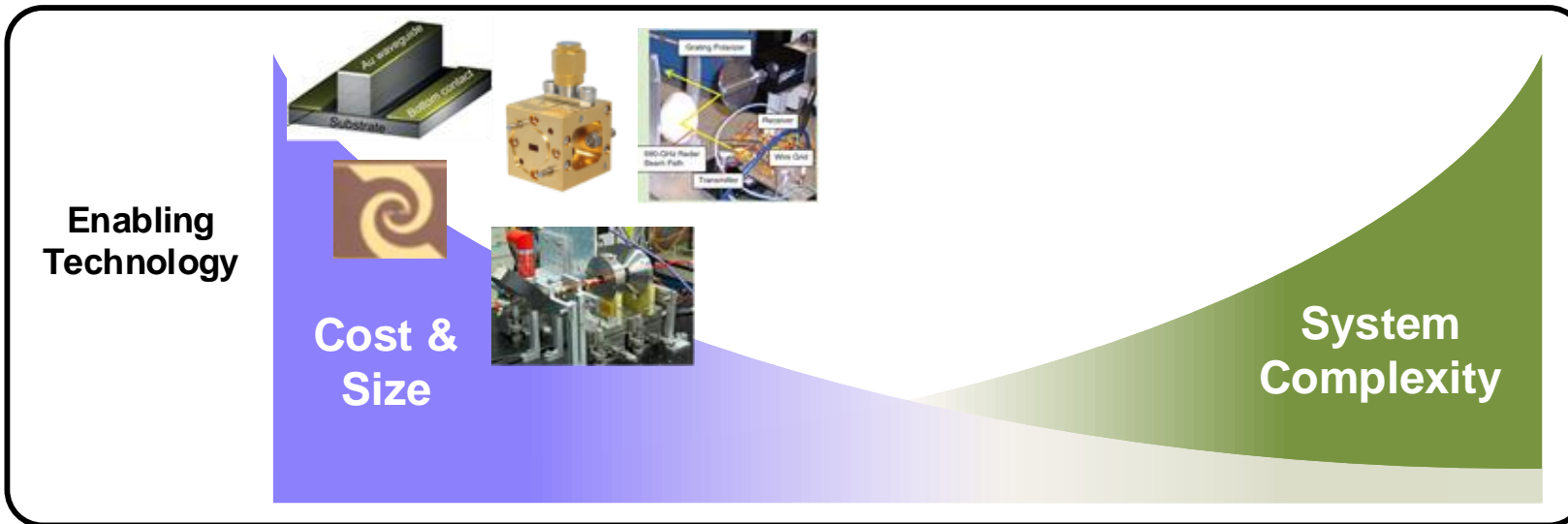
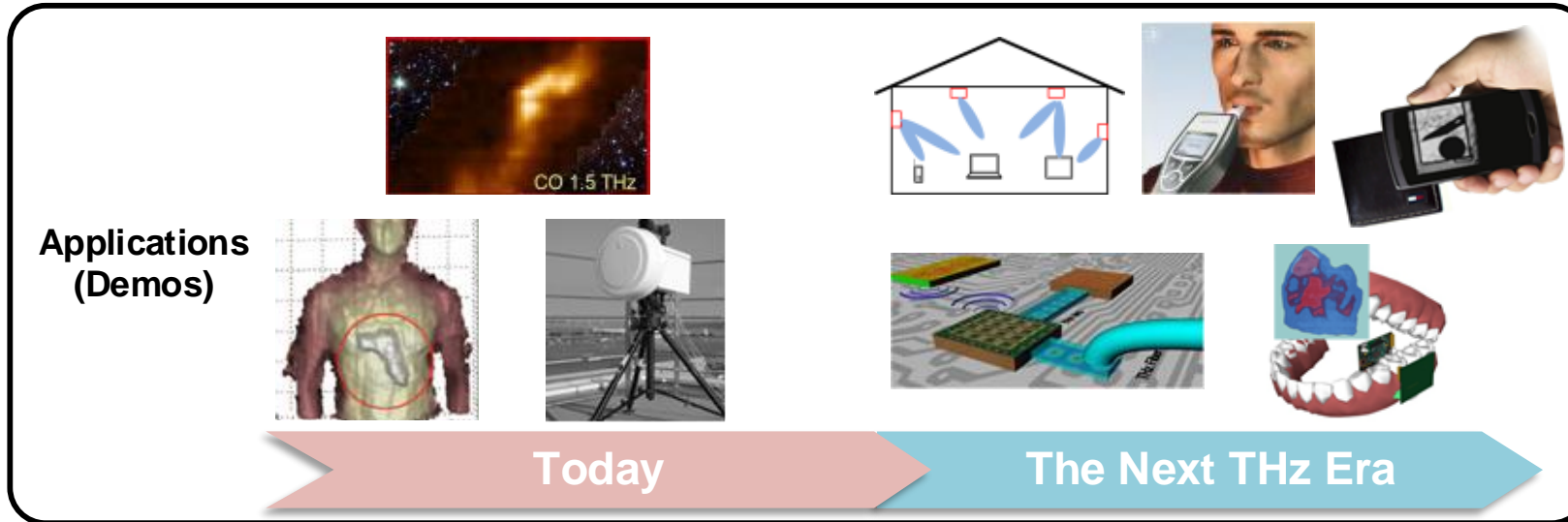


Grating Resonator
ISG-GRIN Resonator Beam Path
Transmitter
Wave Guide
Receiver

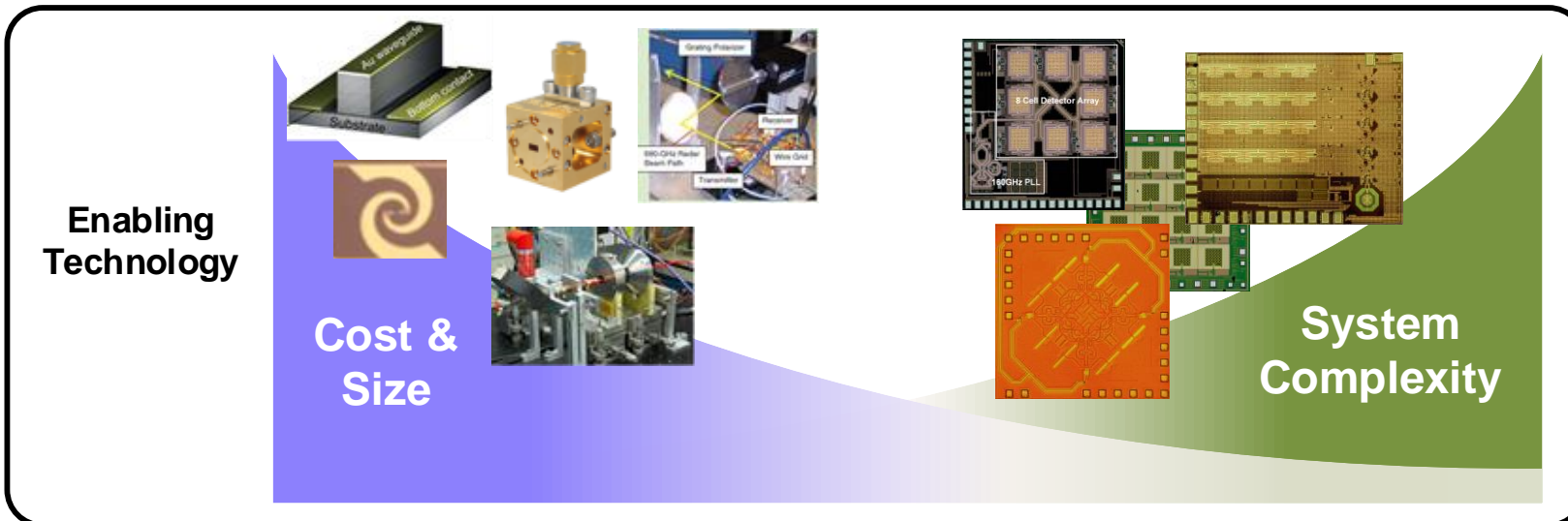
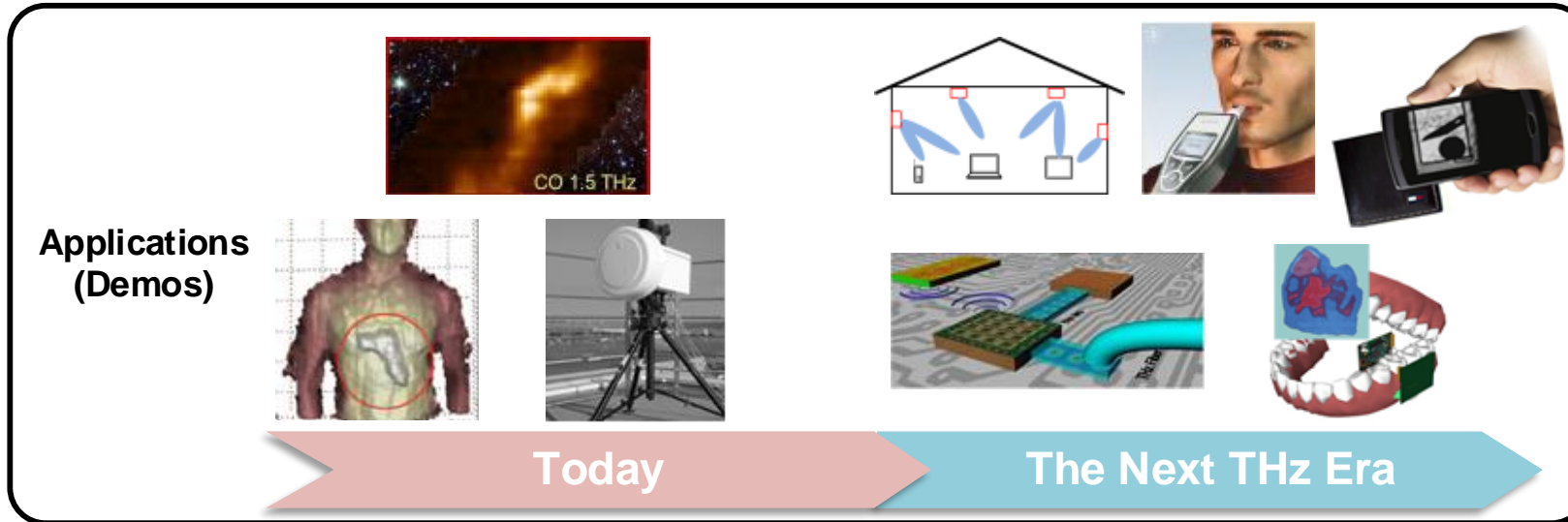


This section details the enabling technologies for terahertz systems. It includes a diagram of a waveguide structure with labels for 'Top waveguide', 'Substrate', and 'Bottom contact'. A photograph shows a microchip with various components labeled: 'Grating Resonator', 'ISG-GRIN Resonator Beam Path', 'Transmitter', 'Wave Guide', and 'Receiver'. A spiral-shaped antenna is also shown, along with a photograph of a microchip assembly on a test bench.

The Dawn of a New Terahertz Era

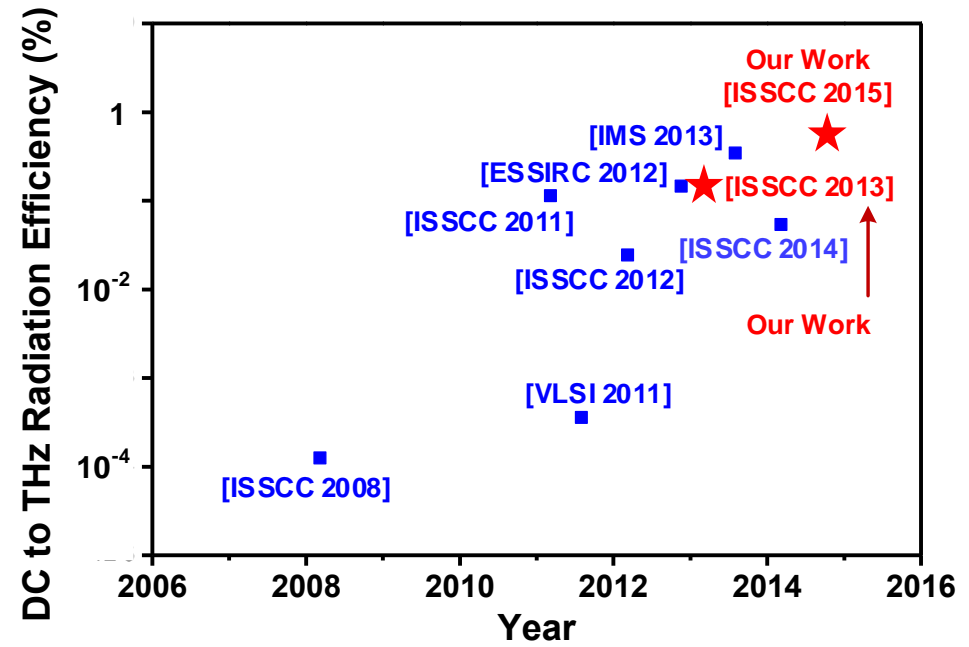
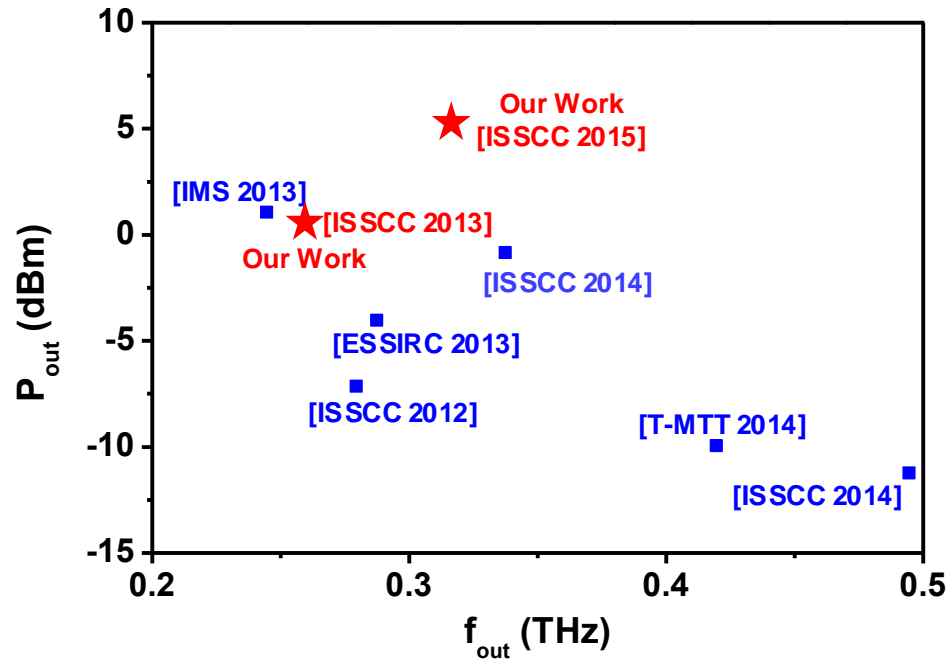


The Dawn of a New Terahertz Era



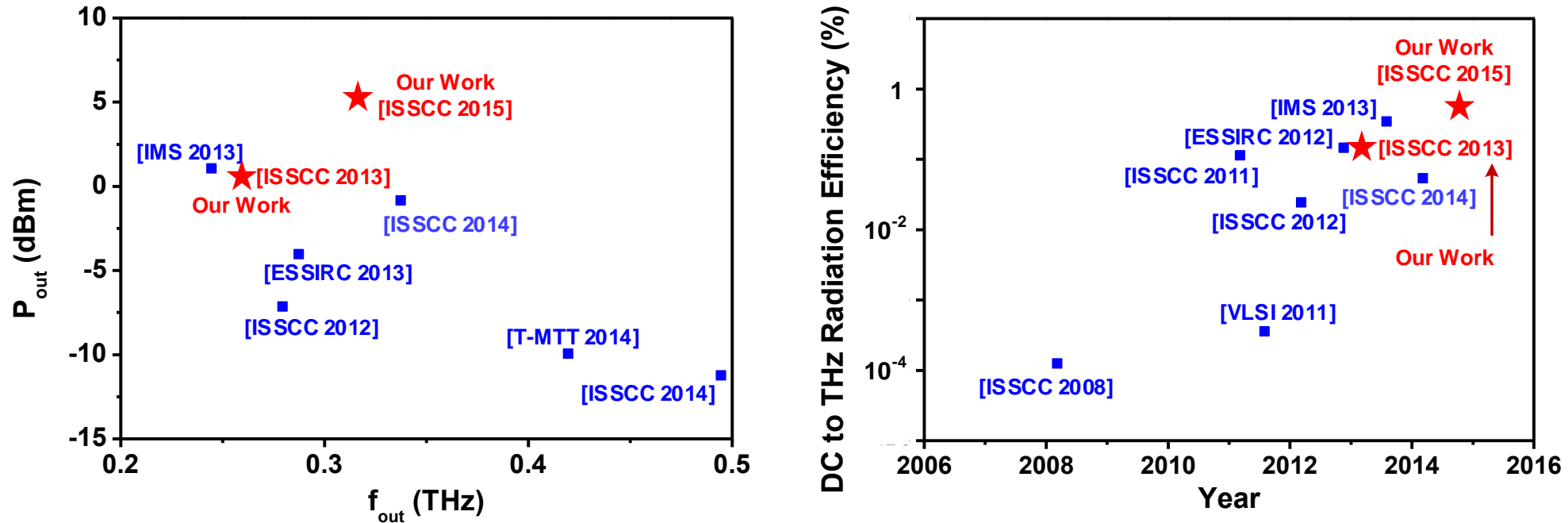
Recent Progress and New Challenges

[R. Han, etc., *IEDM* 2016]



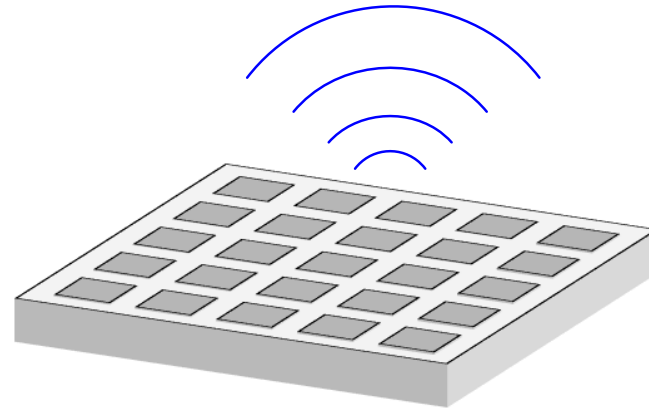
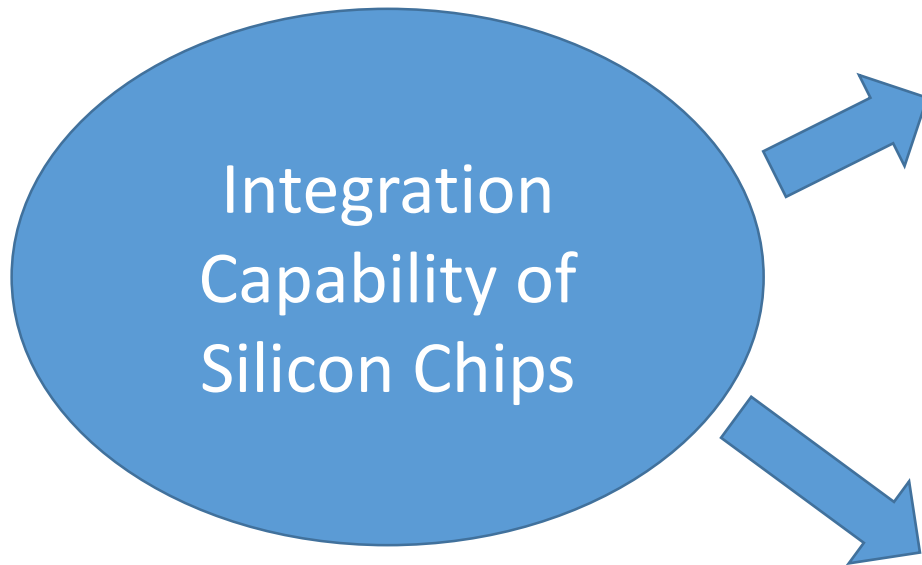
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[R. Han, etc., *IEDM* 2016]



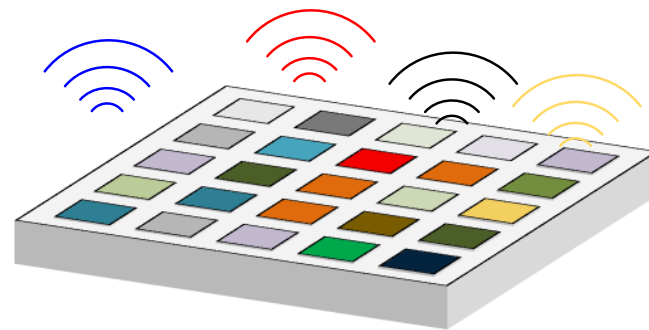
What are the true advantages of using silicon IC for THz hardware (besides low cost, baseband integration...)?

Large-Scale Terahertz Active Array



Homogeneous Array

- Power combining
- Beam collimation
- Beam steering
- ...



Heterogeneous Array

- Broadband sensing
- Parallel signal processing
- Waveform generation
- ...

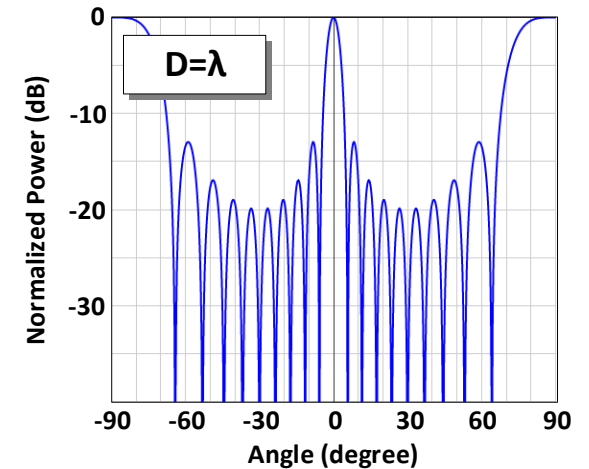
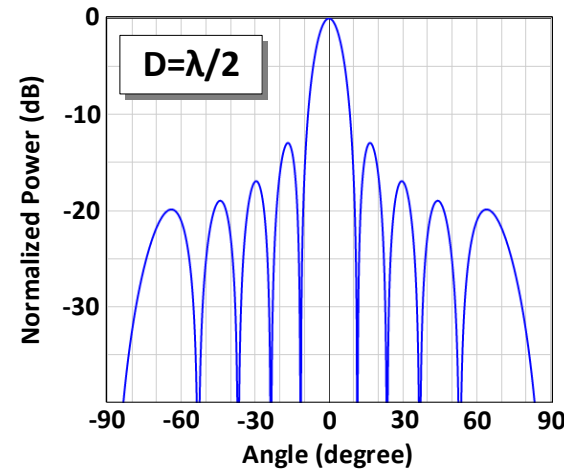
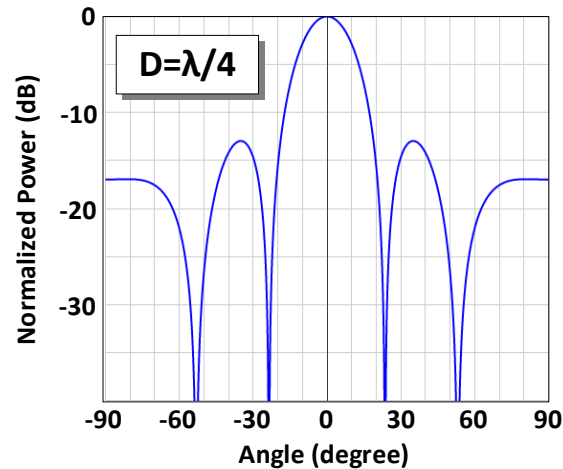
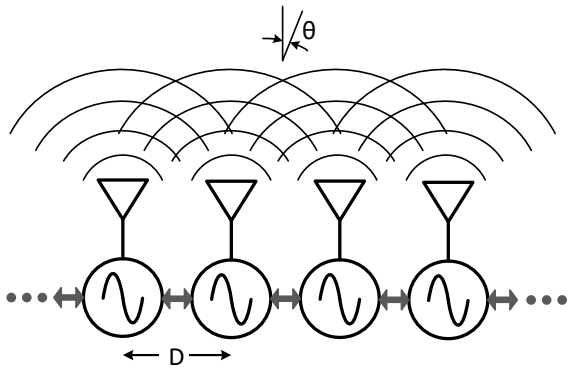
Outline

- Background
- Homogeneous Array: 1-THz Radiation Source
 - Multi-Functional Mesh Structure
 - Chip Prototype in SiGe and Measurement Results
- Heterogeneous Array: 220-to-320GHz Frequency-Comb Spectrometer
 - High-Parallelism Architecture and THz Molecular Probing Module
 - Chip Prototype in CMOS and Measurement Results
 - Gas-Sensing Demonstration
- Conclusion

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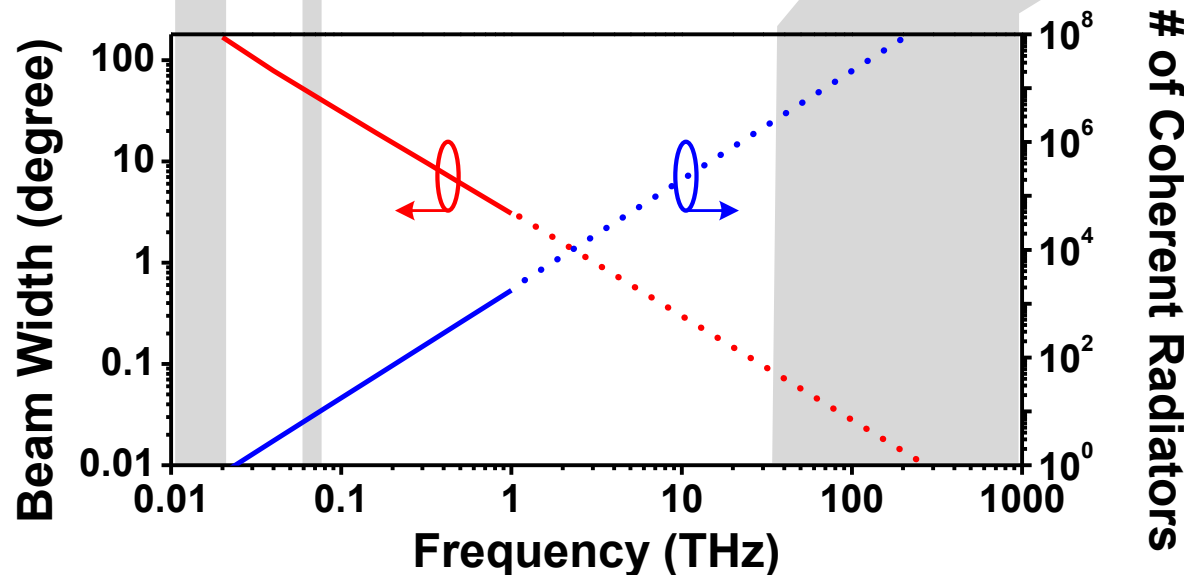
Beam Collimation in a Radiator Array



- Array of N coherent radiation sources enables:
 - Power combining from a large number of solid-state devices
 - Beam collimation through wave interference
 - The far-field radiation intensity increases by N^2

Optimum Element Pitch: $\lambda/2$

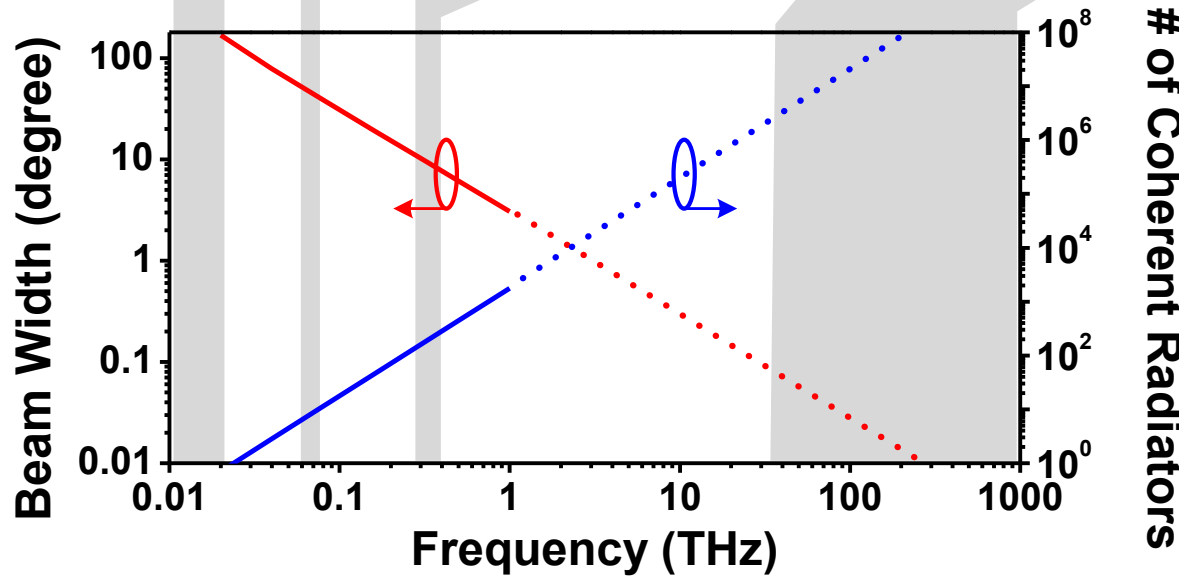
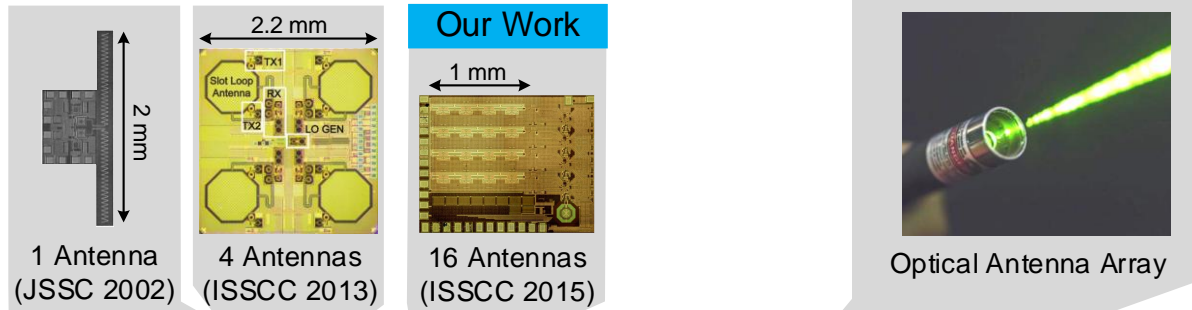
High-Density, Large-Scale Active Array on Chip



Note: Calculations Based on a 10mm² Active Area

- If the $\lambda/2$ pitch is achieved:
 - $>10/\text{mm}^2$ radiators at 300 GHz can be built
 - D_{opt} is $\sim 300\mu\text{m}$ (with $\epsilon_{r,\text{eff}} \approx 3$)
- High effective isotropically radiated power (EIRP) may be maintained in the mid-THz range
 - Long transmission distance

High-Density, Large-Scale Active Array on Chip

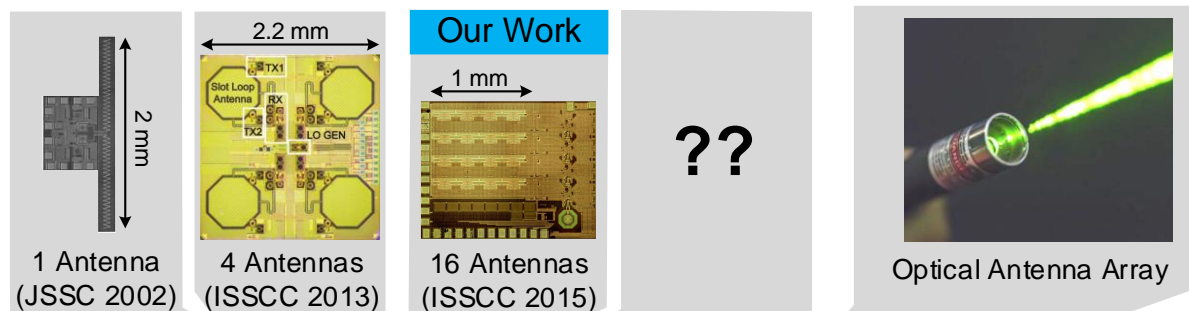


Note: Calculations Based on a 10mm² Active Area

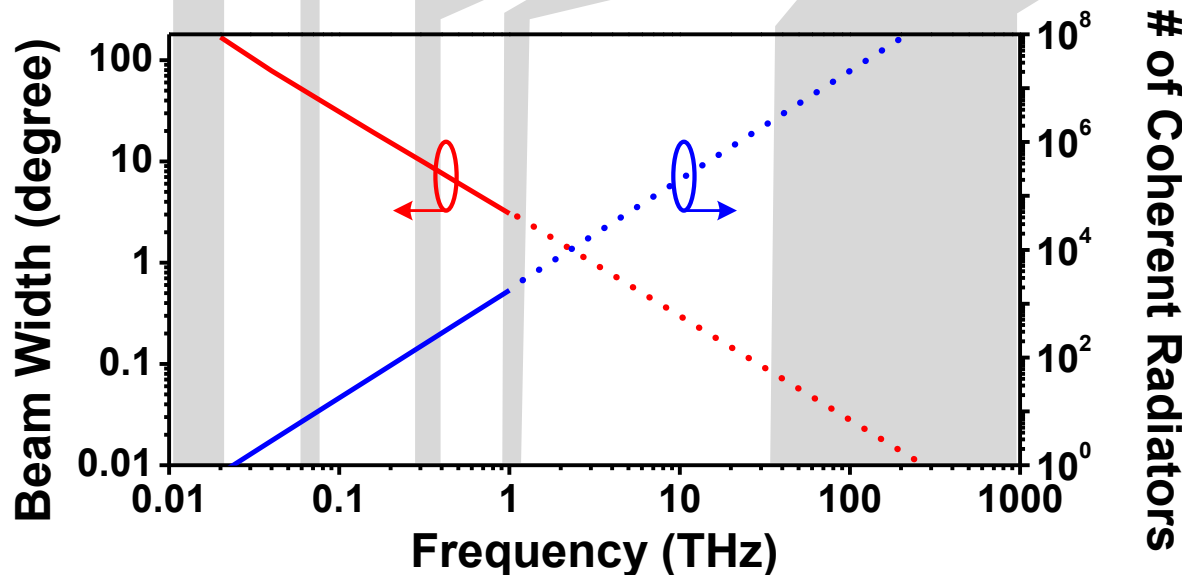
[R. Han, ISSCC 2015]

- 320-GHz Array w/ PLL in SiGe BiCMOS
- 4x4 elements in 1-mm² area
- 3.3mW total radiated power (EIRP: 24mW)

High-Density, Large-Scale Active Array on Chip



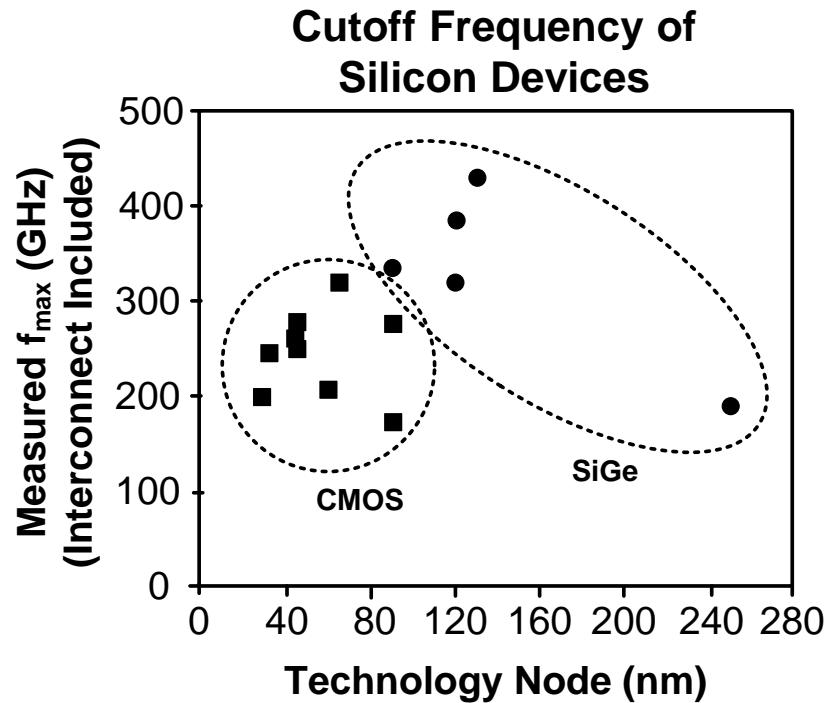
- $\sim 100/\text{mm}^2$ radiator density should be possible
 - Only 3° of beamwidth using 10-mm^2 chip area (~ 1000 coherent radiators)



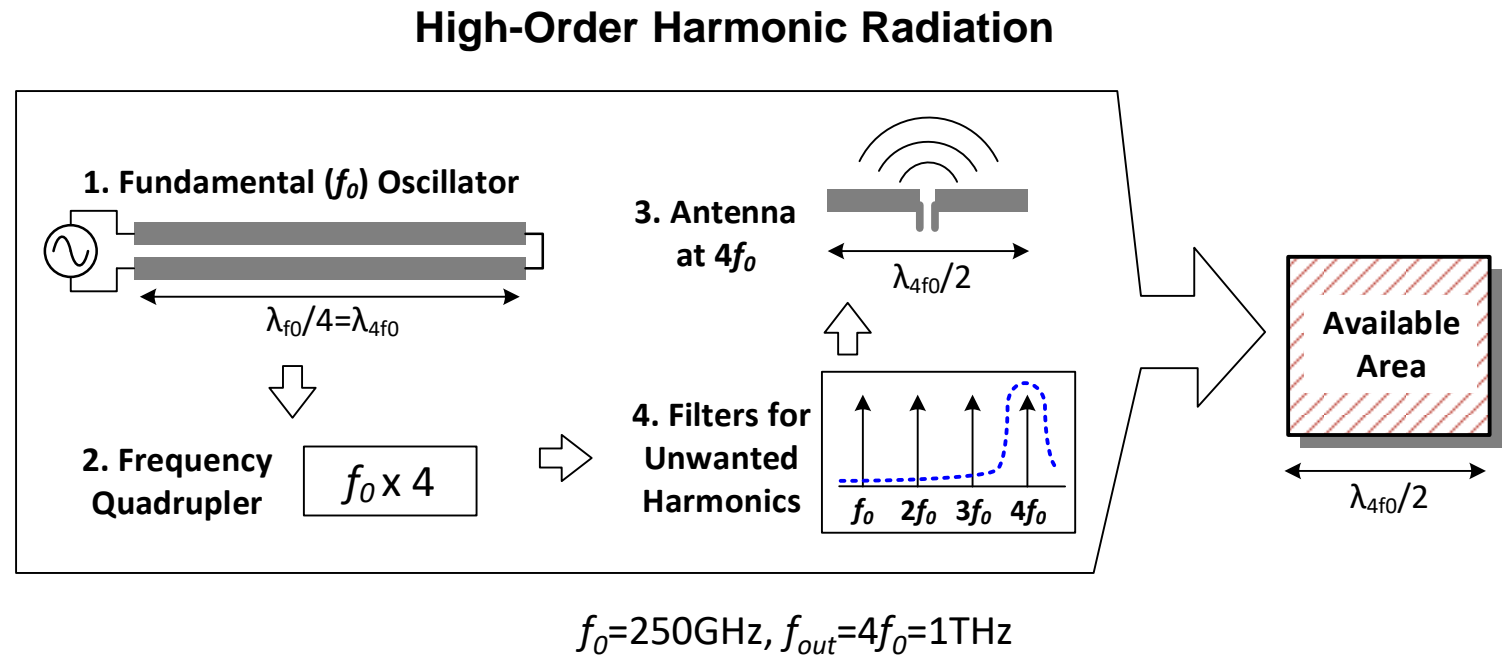
Note: Calculations Based on a 10mm^2 Active Area

- Large challenges
 - Signal generation at 1 THz
 - Available radiator area: $100 \times 100 \mu\text{m}^2$
 - Highly scalable array architecture

Implementation Challenges

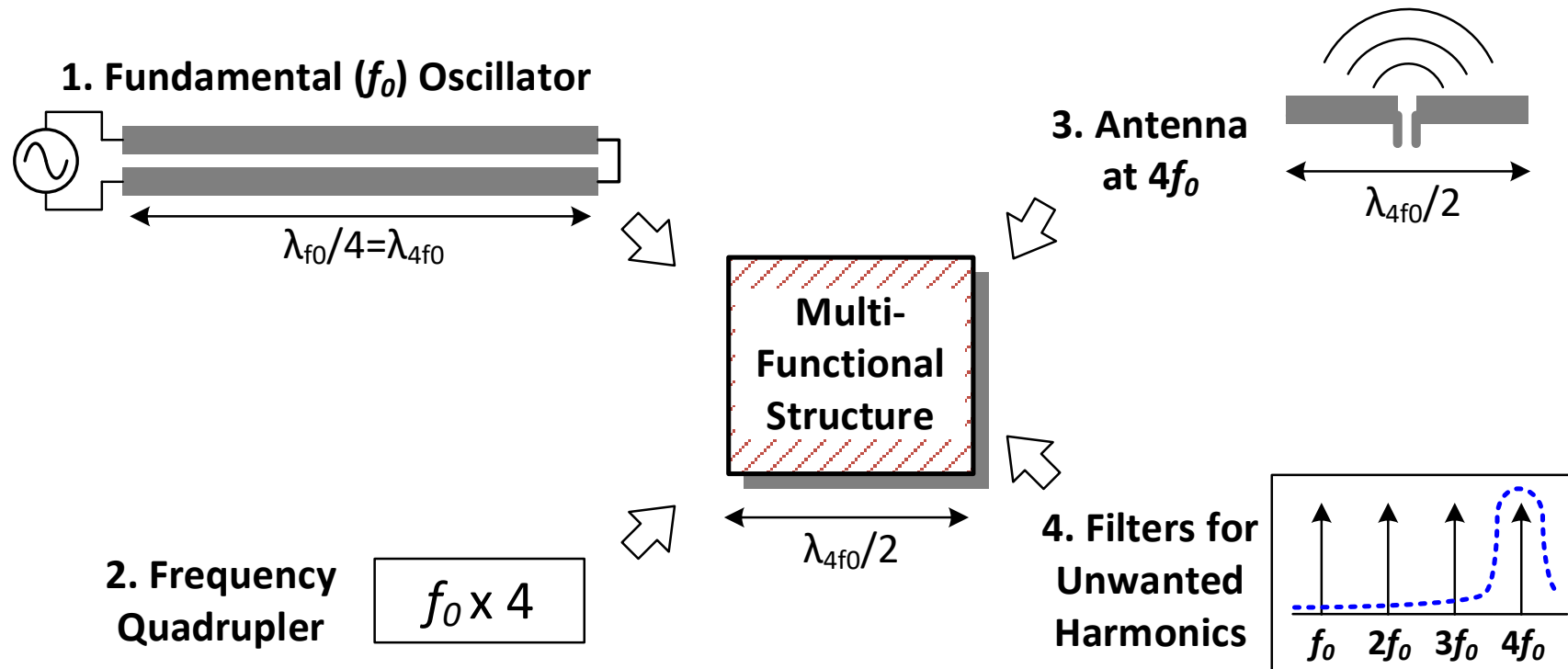


[R. Schmid, et al., IEEE Trans. Electron Devices 2015]



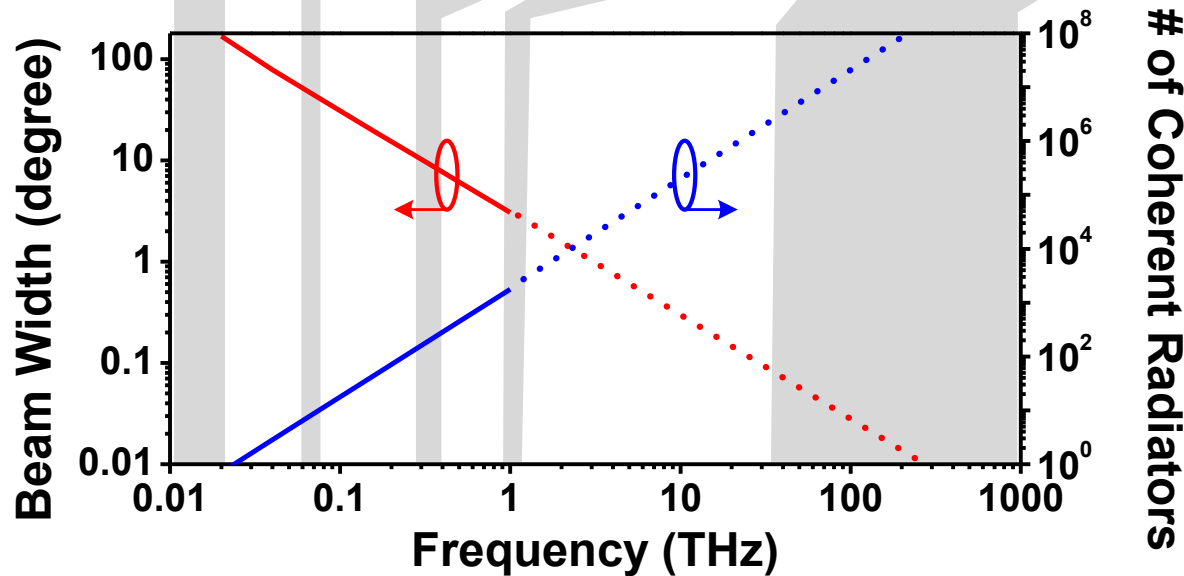
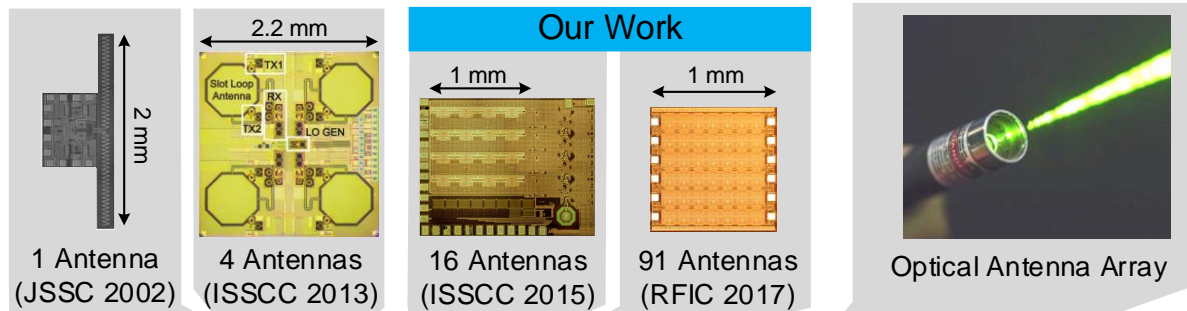
- Low device speed requires high-order harmonic generation
 - Optimal device conditions at all harmonic frequencies should be met
- The available area is **too small** for all these necessary functions

Enabling Technology: Versatile EM Designs



- A multi-functional electromagnetic structure around the transistors to simultaneously perform all the above tasks
 - Orthogonality of various EM wave modes
 - Multi-order standing-wave interference in the near field

High-Density, Large-Scale Active Array on Chip



Note: Calculations Based on a 10mm² Active Area

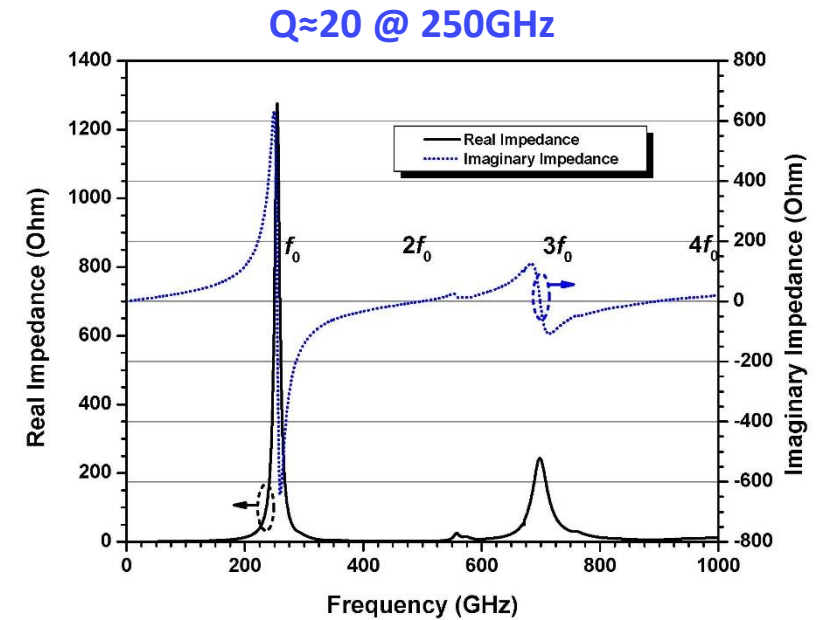
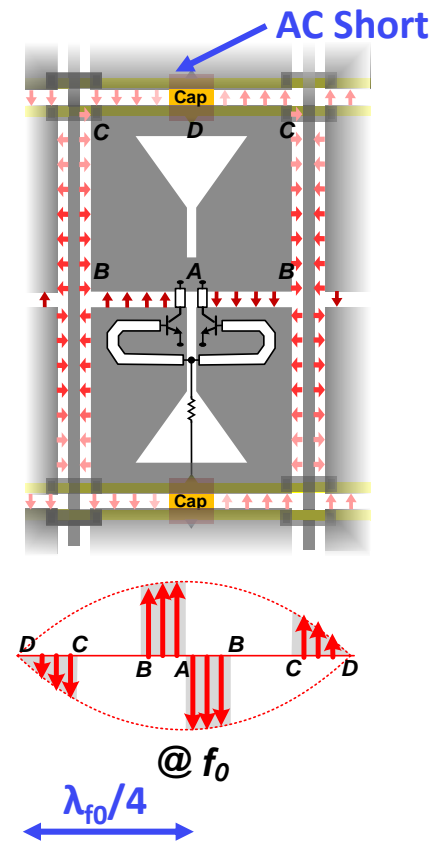
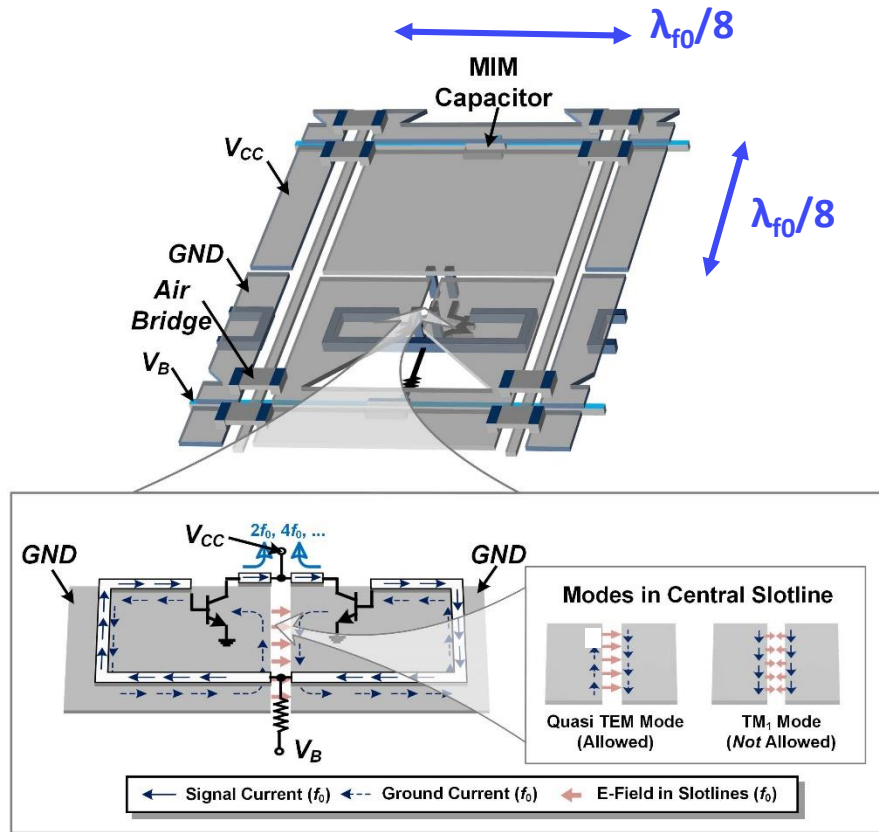
1 mm

- 1-THz Array in 130-nm IHP SiGe BiCMOS
- 91 coherent radiator in 1-mm² area
- 0.1-mW total radiated power (EIRP: 20mW)

[Z. Hu and R. Han, *IEEE RFIC*, Jun. 2017 (Best Student Paper Award-2nd Place)]

The figure shows a micrograph of the 1-THz array with a 1 mm scale bar. A dashed box indicates the area shown in the 3D schematic to the right, which depicts the array structure with radiators and feedlines.

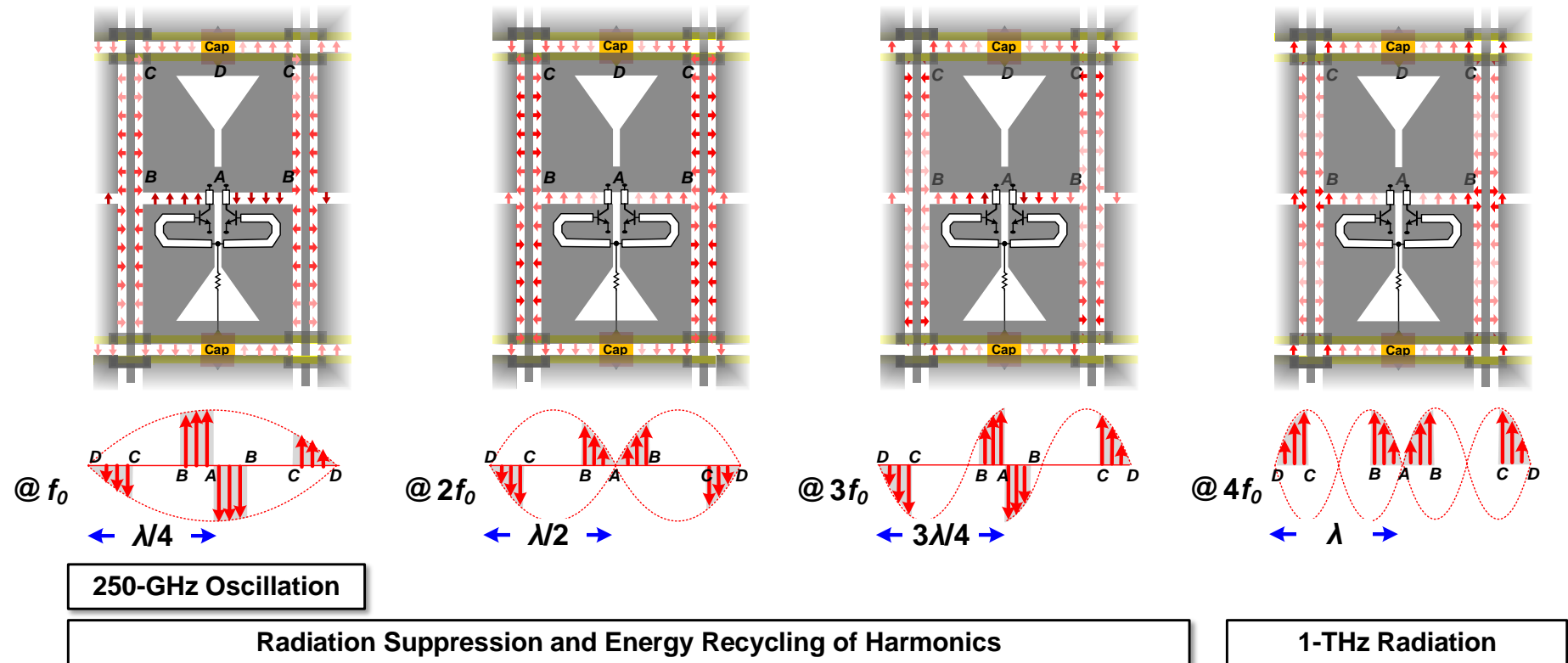
Fundamental Oscillation at $f_0=250\text{GHz}$



- At f_0 , each square slot line behaves as a pair of $\lambda/4$ standing-wave resonators

Optimal Fundamental Oscillation

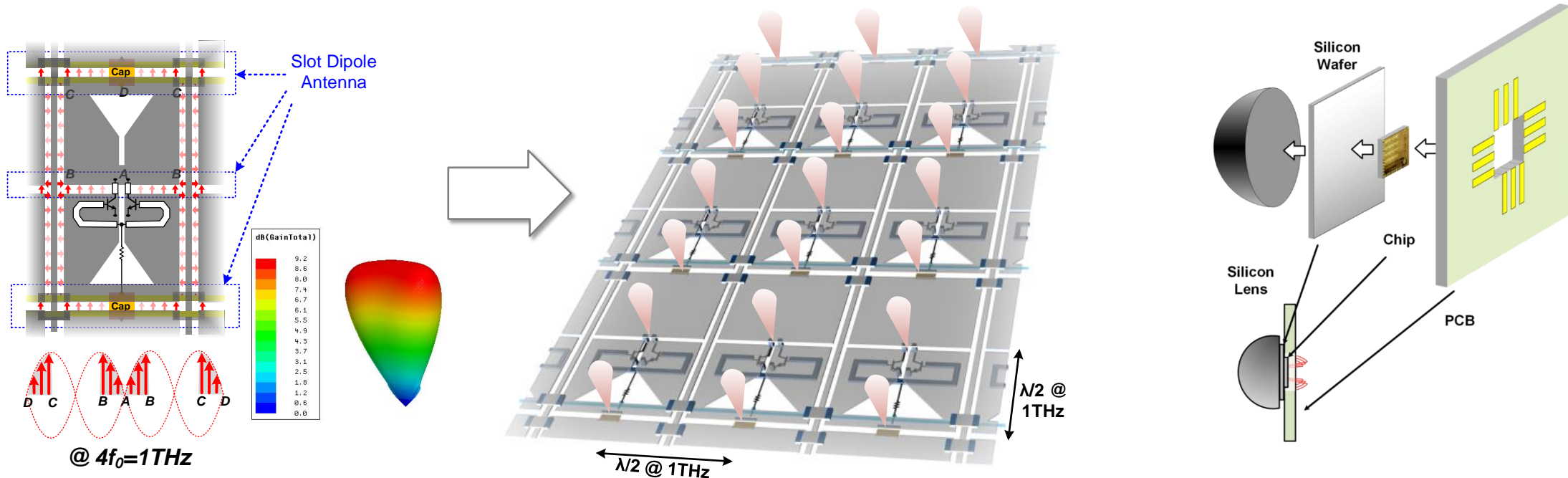
Multi-Order Standing Wave Interference



- Unwanted harmonics ($@ f_0, 2f_0, 3f_0$) are canceled by near-field interference

No Separate Filter is Needed

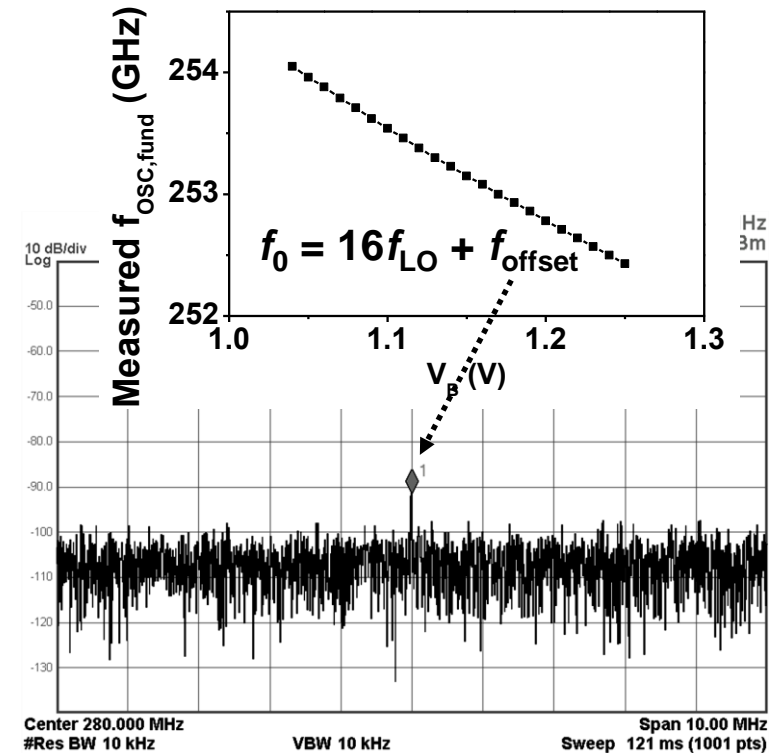
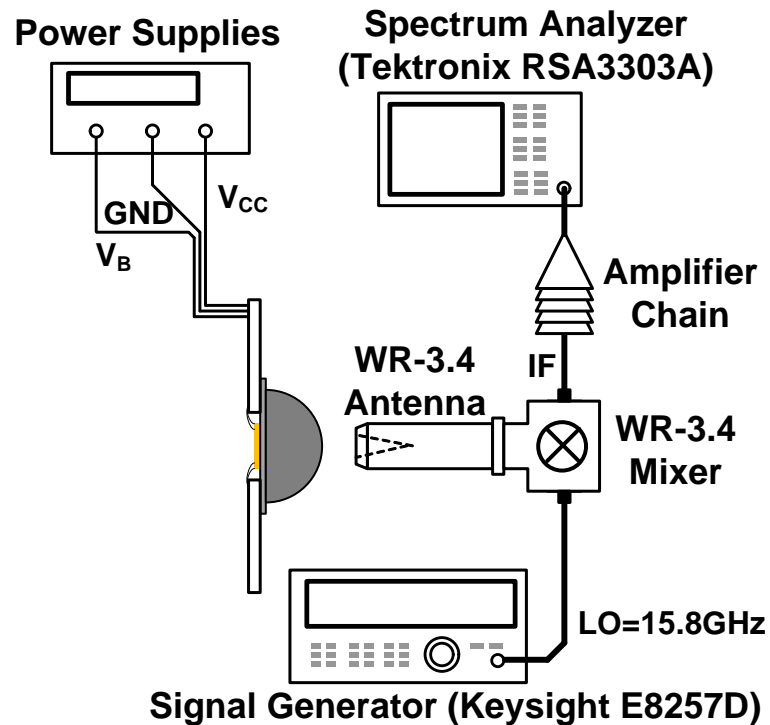
High-Density Radiation at 1 THz



- The 1-THz standing waves in all horizontal slots are in phase
 - Effective backside radiation ($\eta_{\text{rad,sim}}=63\%$)
 - On average, each oscillator (4x7 in total) drives 2 slot dipole antennas

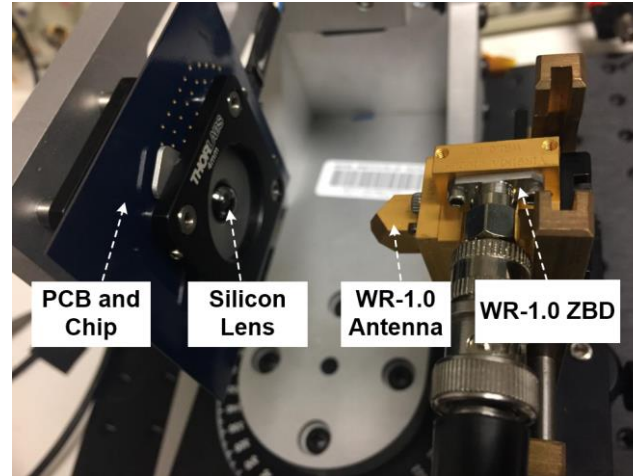
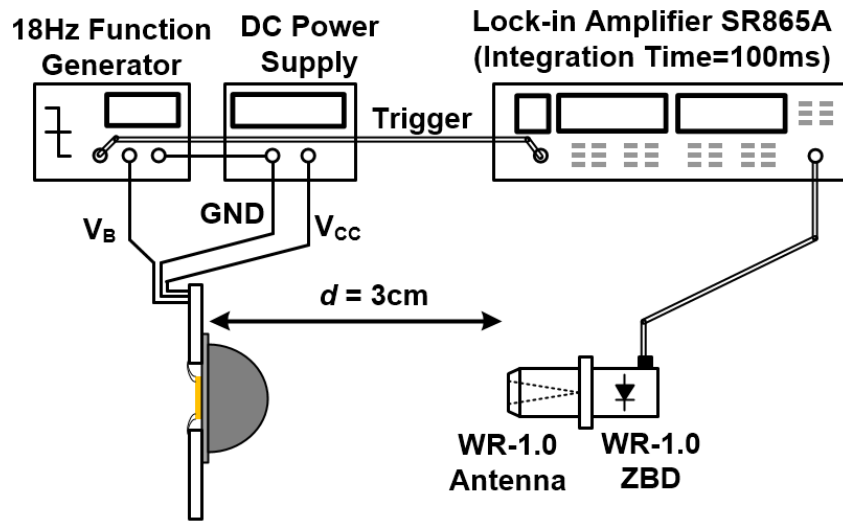
91 Coherent Antennas ($D \approx \lambda/2$)

Measurement Results: Frequency and Spectrum

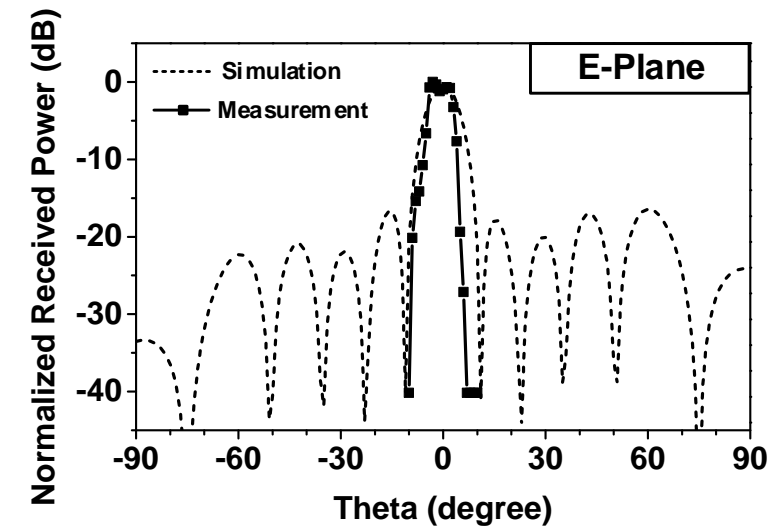
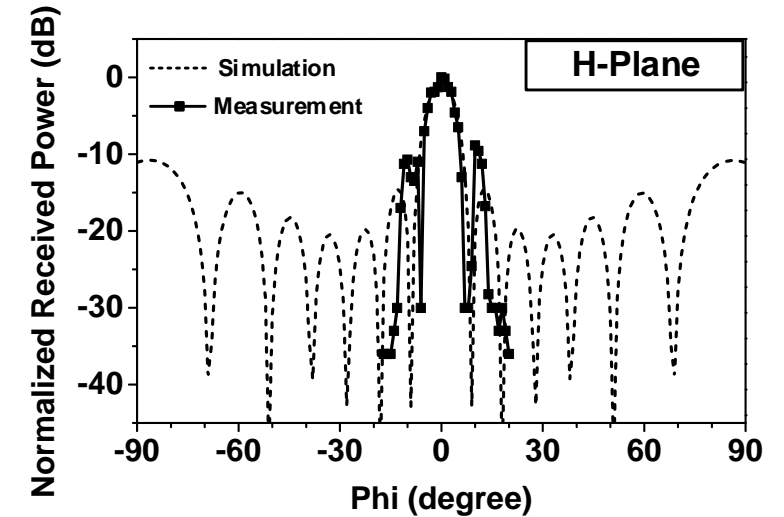


- Oscillation frequency is determined by a sub-harmonic SBD mixer
 - Weak radiation leakage at f_0
 - Measured fundamental frequency: 252.5 to 254.1 GHz
 - $4f_0$ output: 1.01 to 1.016 THz

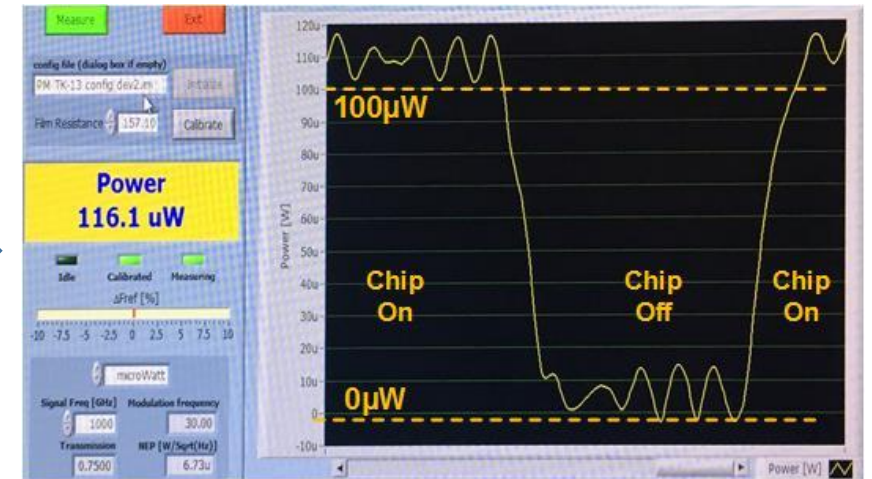
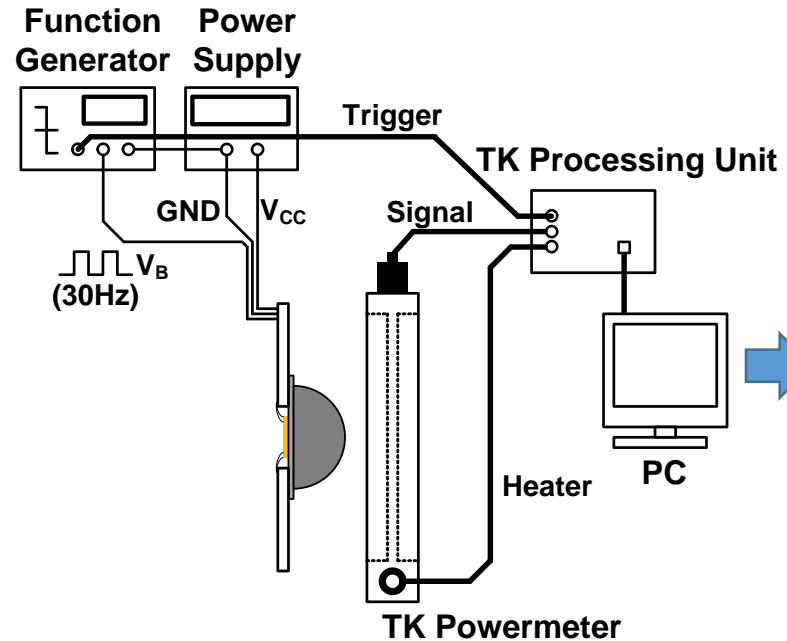
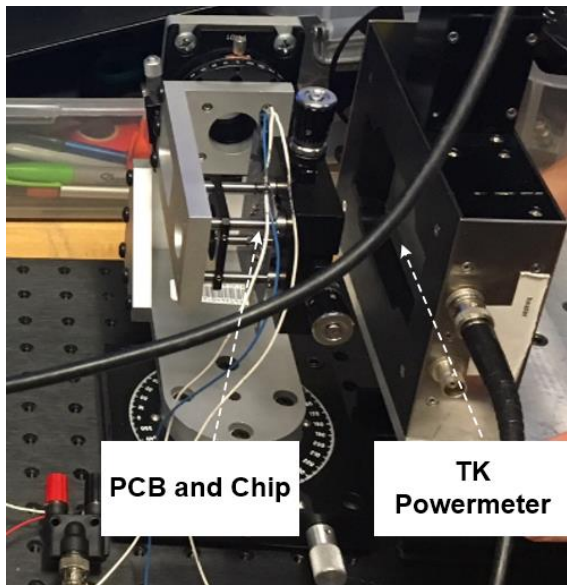
Measurement Results: Radiated Power



- The radiated power is measured by a calibrated WR-1.0 zero-biased diode detector
 - Measured total radiated power: $80 \mu\text{W}$
 - Measured beam directivity: 24 dBi ($\theta_{-3\text{dB}} = 11^\circ$)
 - Measured EIRP: 20 mW

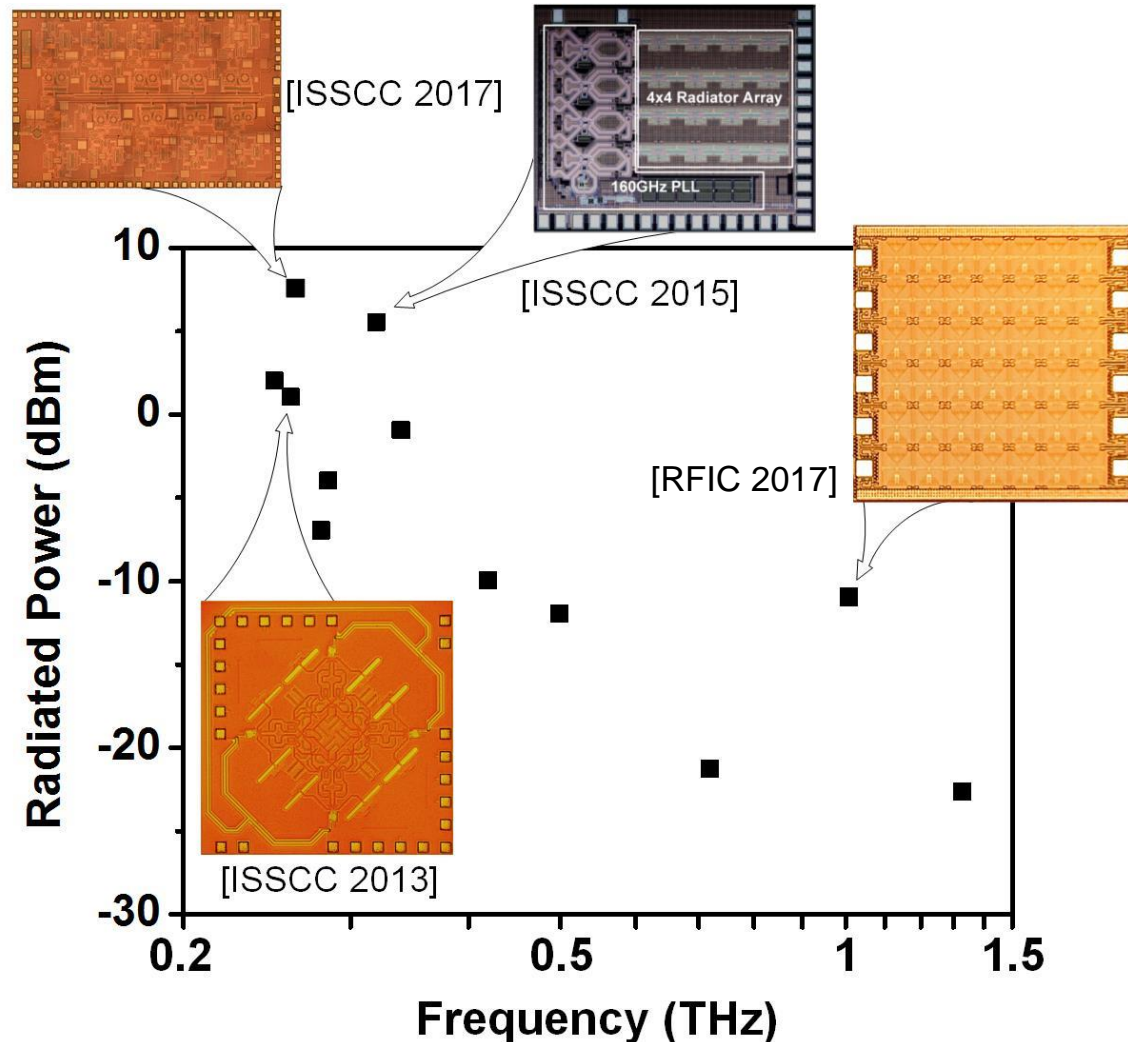


Measurement Results: Radiated Power



- The measured radiated power is further verified by a photo-acoustic (TK) power meter with large aperture

Comparison with the State-of-the-Arts in Silicon

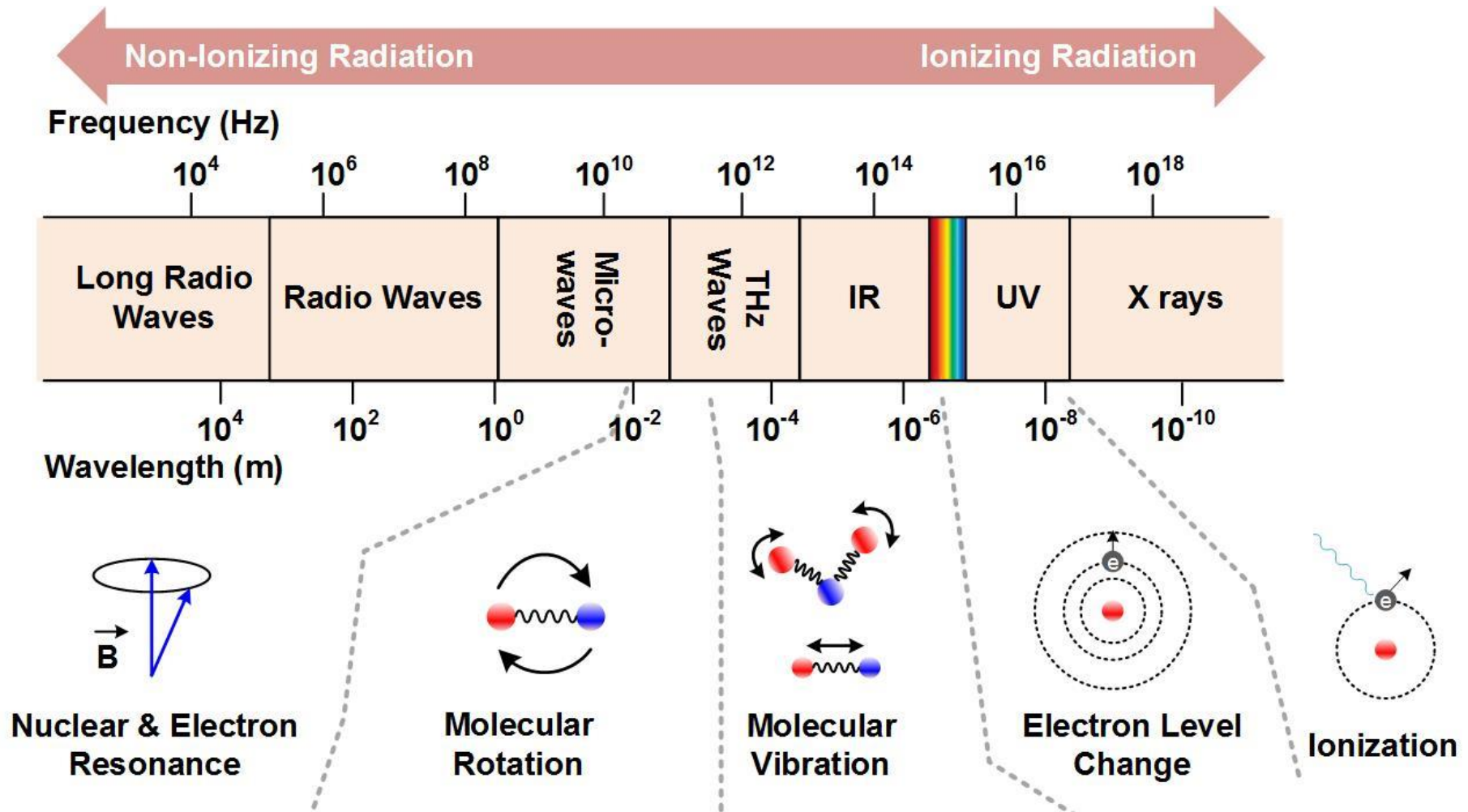


- The achieved radiated power is 10x higher than prior silicon-based radiation sources in the mid-THz range
 - 100x higher EIRP than prior arts
- Even larger scale with higher power should be possible

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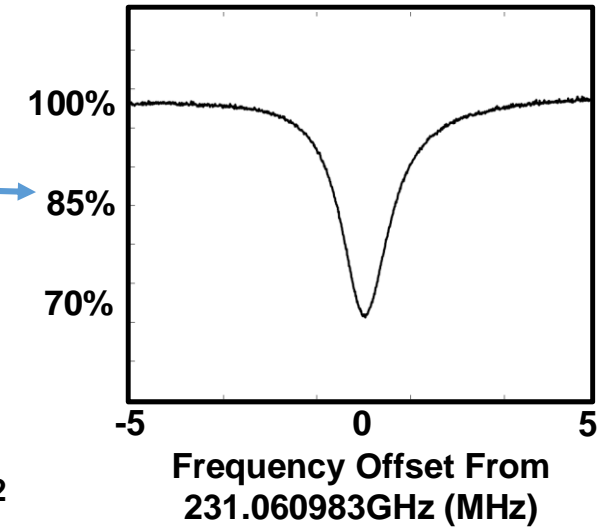
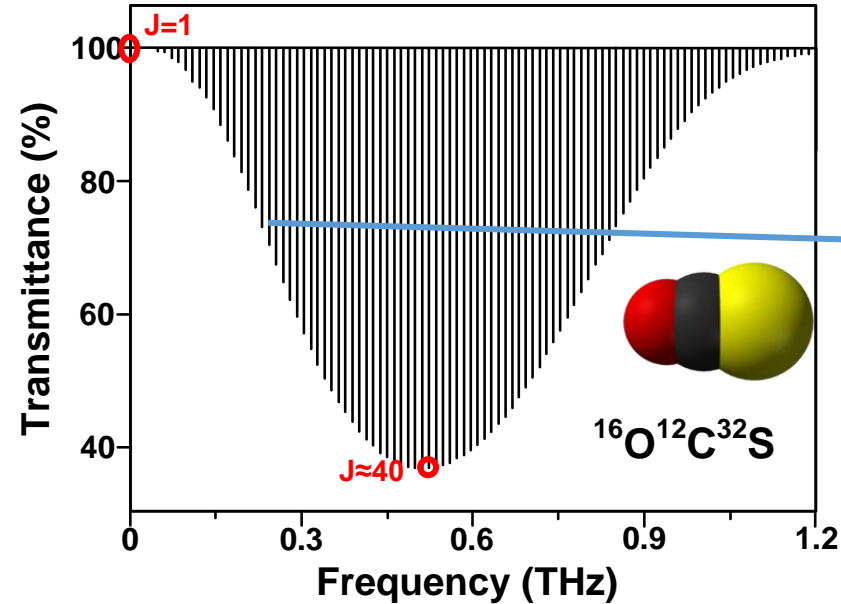
Wave-Matter Interactions for Material Sensing



THz Spectrometer for Gas Sensing

[Source: HITRAN.org]

| Molecule | Frequency (GHz) | Toxic? | Flammable? |
|--|-----------------|--------|------------|
| Carbon Monoxide (CO) | 230.538001 | Y | Y |
| Sulfur Dioxide (SO ₂) | 251.199668 | | |
| Hydrogen Cyanide (HCN) | 265.886441 | | Y |
| Hydrogen Sulfide (H ₂ S) | 300.511959 | | Y |
| Nitric Oxide (NO) | 250.436966 | Y | |
| Nitrogen Dioxide (NO ₂) | 292.987169 | Y | |
| Nitric Acid (HNO ₃) | 256.657731 | Y | |
| Ammonia (NH ₃) | 208.145904 | Y | |
| Carbonyl Sulfide (OCS) | 231.060989 | Y | Y |
| Ethylene Oxide (C ₂ H ₄ O) | 263.292515 | Y | |
| Acrolein (C ₃ H ₄ O) | 267.279359 | Y | |
| Methyl Mercaptan (CH ₃ SH) | 227.564672 | Y | |
| Methyl Isocyanate (CH ₃ NCO) | 269.788609 | Y | |
| Methyl Chloride (CH ₃ Cl) | 239.187523 | Y | Y |
| Methanol (CH ₃ OH) | 250.507156 | Y | Y |
| Acetone (CH ₃ COCH ₃) | 259.6184 | Y | Y |
| Acrylonitrile (C ₂ H ₃ CN) | 265.935603 | Y | Y |



Quantum Number

$$\text{Absorption Intensity: } \gamma = \frac{(2J + 1)hB e^{-hBJ(J+1)/kT}}{kT}$$

Wide Detection Range



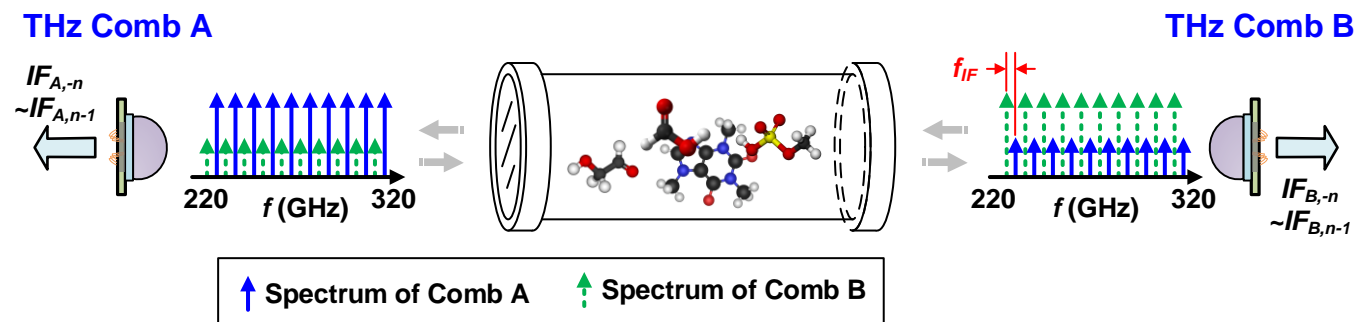
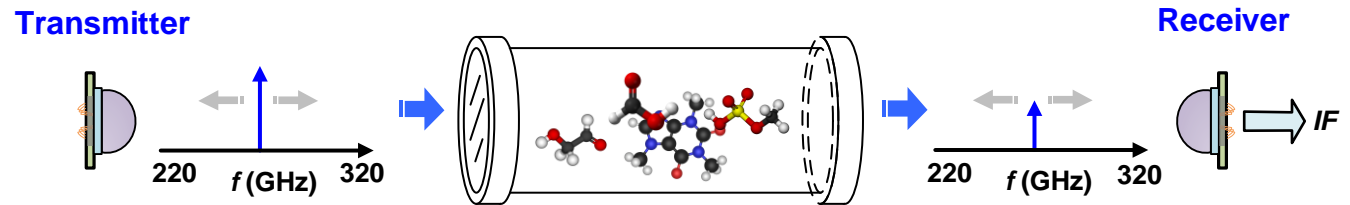
High Sensitivity



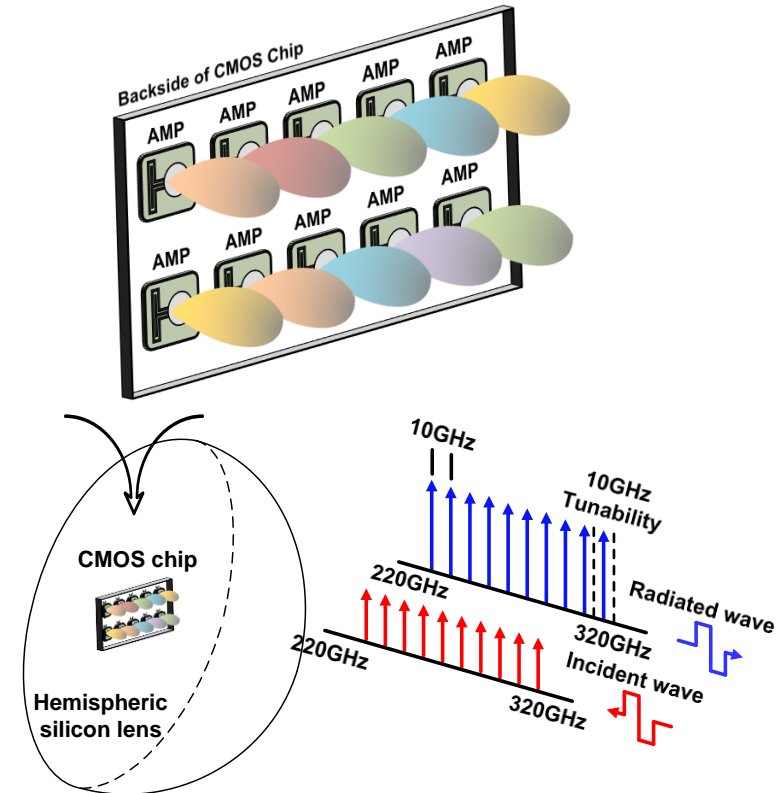
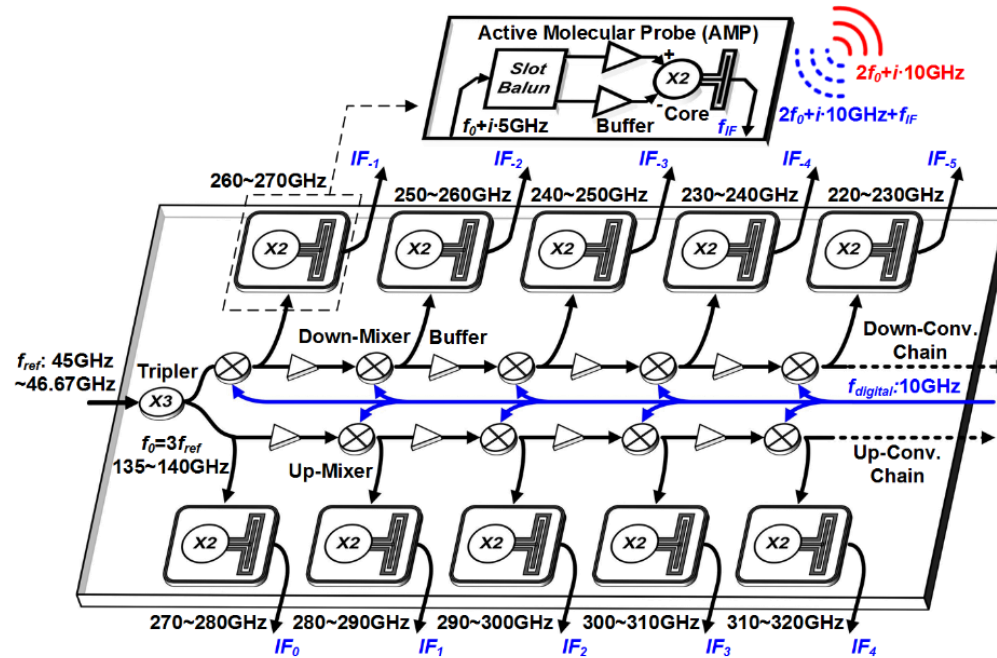
High Selectivity

Dual-THz-Comb Spectrometer

- Conventional single-tone sensing scheme
 - Bandwidth-efficiency tradeoff
 - Long scanning time (~3 hours for 100-GHz bandwidth)
- Our scheme using bilateral THz frequency combs
 - Each circuit block maintains peak performance in a narrow band
 - Simultaneous scanning using 20 comb lines (>20x increased speed)



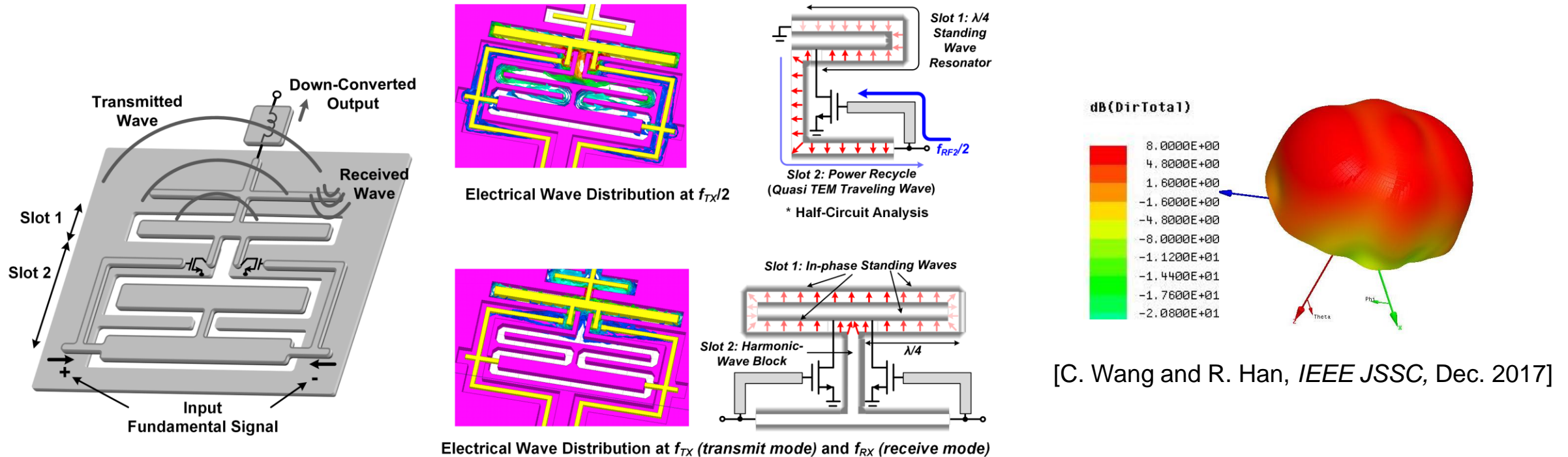
220-to-320GHz Comb-Based CMOS Spectrometer



[C. Wang and R. Han, *IEEE ISSCC*, Feb. 2017]

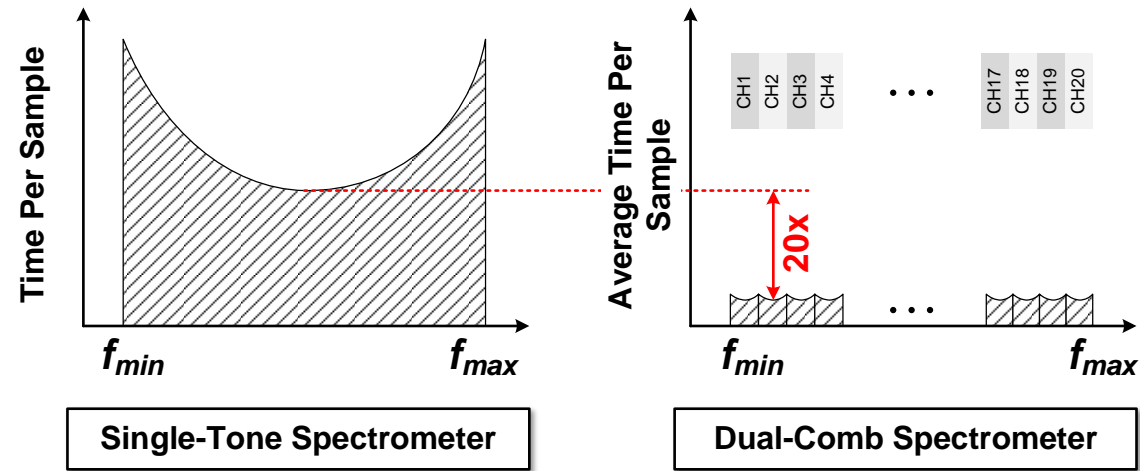
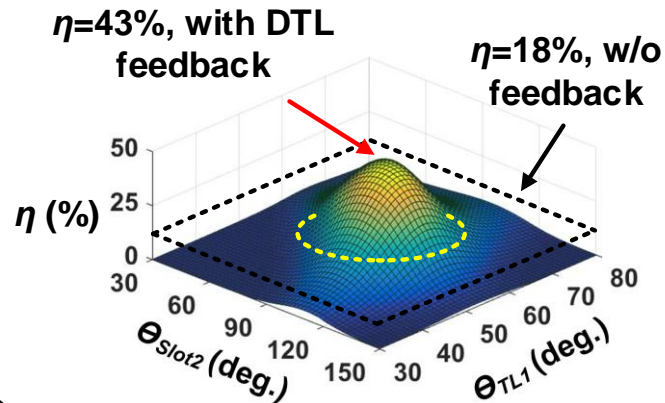
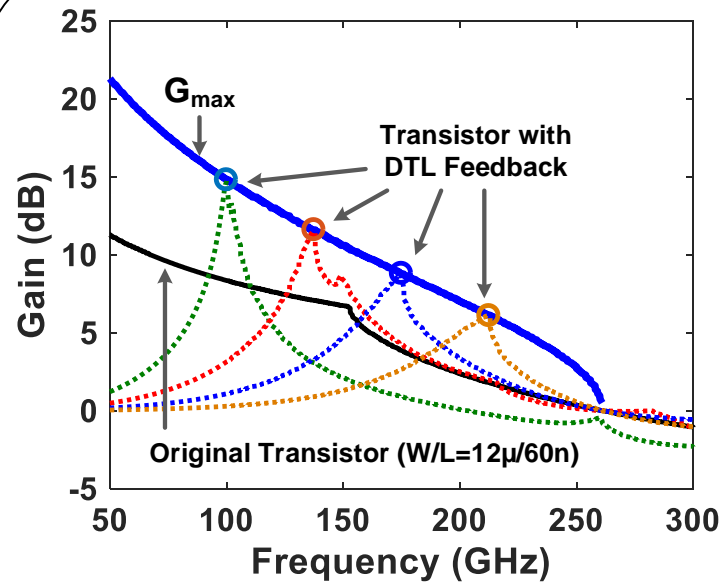
- 10 molecular-probing THz transceivers
 - Key technology: multi-function, energy-efficient electromagnetic structures
- Seamless coverage of the 220 to 320 GHz band with kHz resolution

Operation of the Transceiver Unit Core



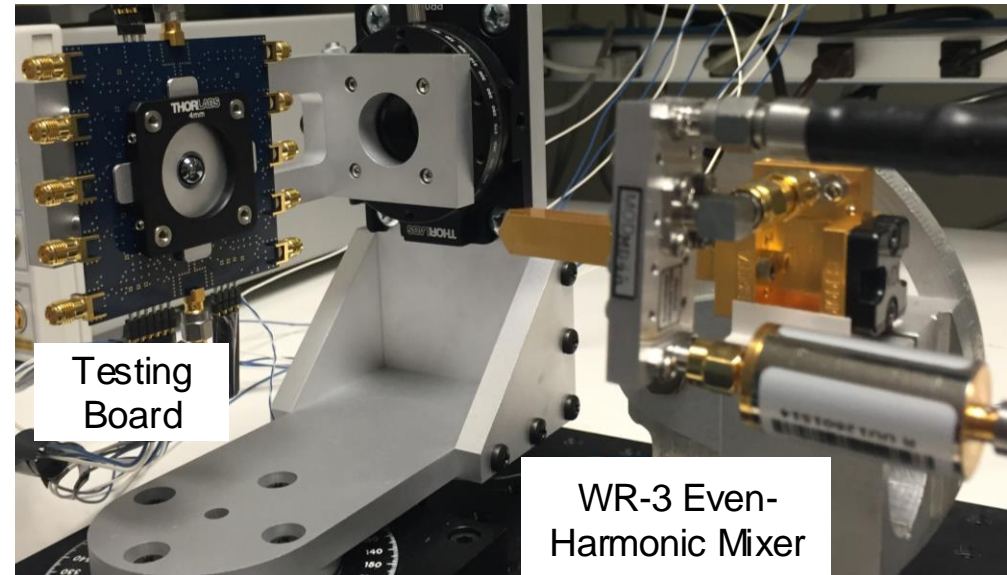
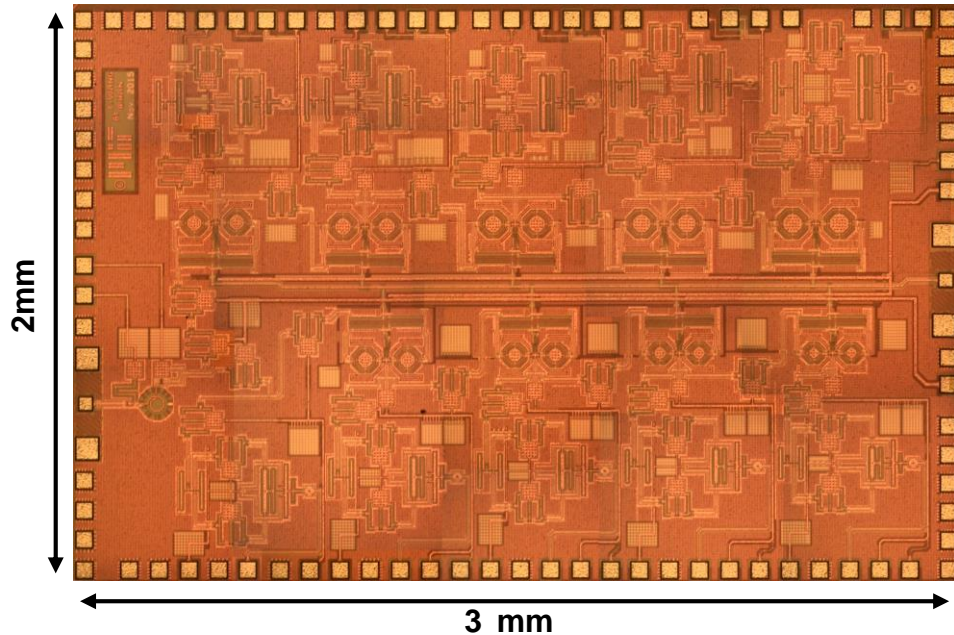
- Optimum device conditions created via a multi-functional EM structure
 - Slot 1: resonator at f_0 and antenna at $2f_0$
 - Slot 2: power recycle path at f_0 and leakage blocker at $2f_0$
- Simultaneous transmit/receive function

High-Parallelism Broadband Architecture



- The relaxed tunability requirement allows the introduction of device positive feedback and higher device gain
 - 43% simulated doubler conversion efficiency
- The total spectral scanning time is reduced by more than 20x, leading to high energy efficiency

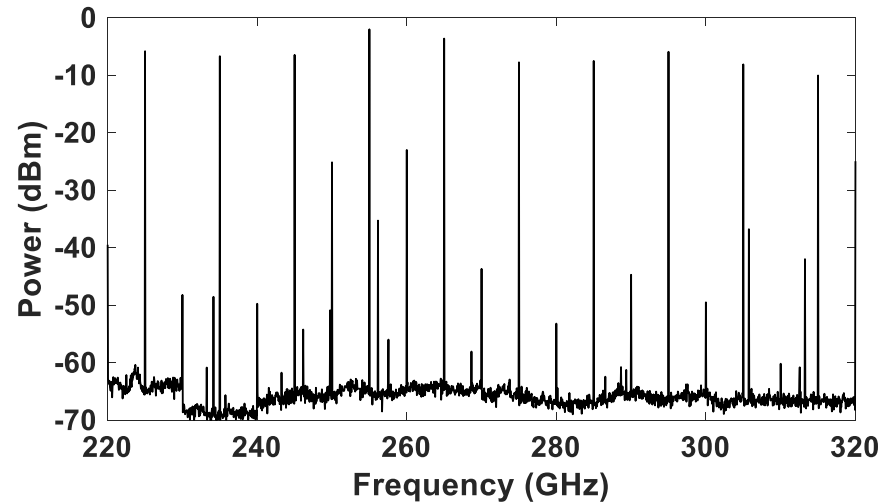
CMOS Chip Prototype



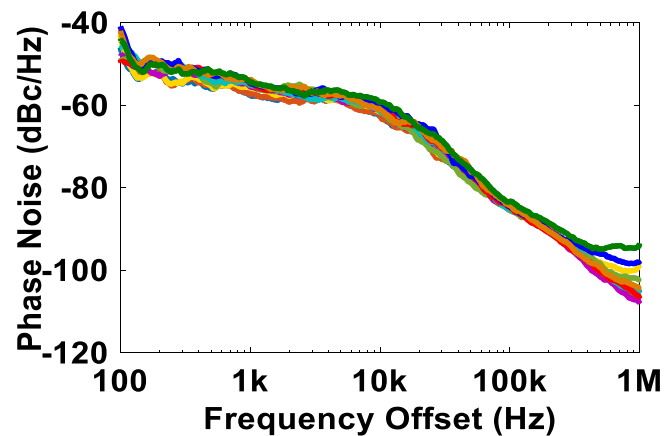
Setup for Radiation Spectrum and Pattern Testing

- TSMC 65nm bulk CMOS process ($f_{max}=250\text{GHz}$)
 - Chip area: $2\times 3\text{mm}^2$
- 10 transceivers (doubler+receiver+antenna), 9 mixers, 40 amplifiers, operating at 0.1~0.3 THz
 - DC power: 1.7 W

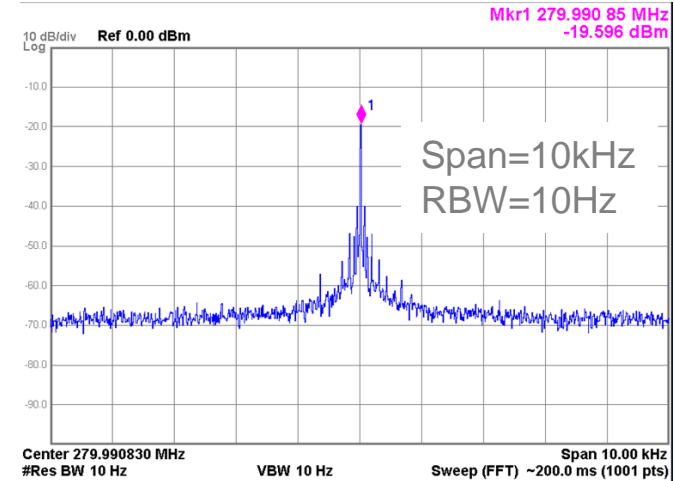
Experimental Results



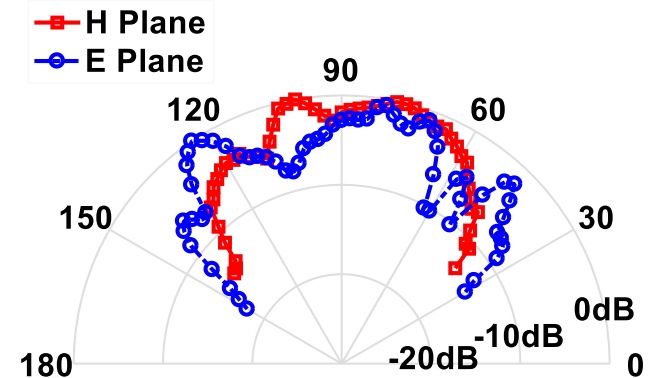
Measured Down-converted IF Spectra of all Comb Lines



Average Phase Noise: -102dBc/Hz @ 1MHz



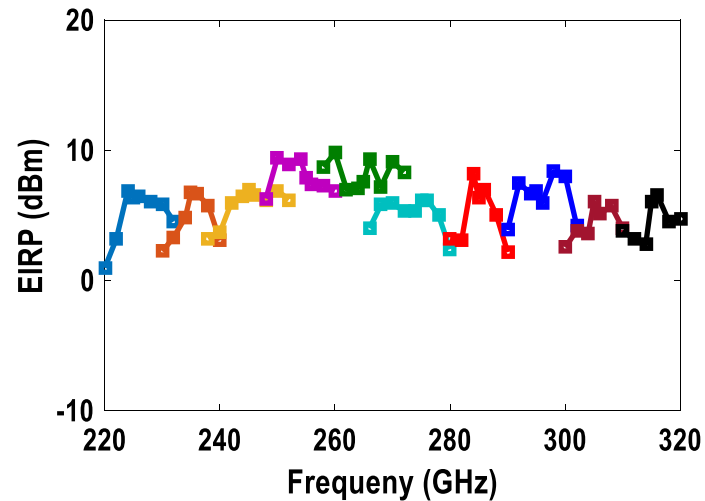
Spectrum of a Comb Line at 265GHz



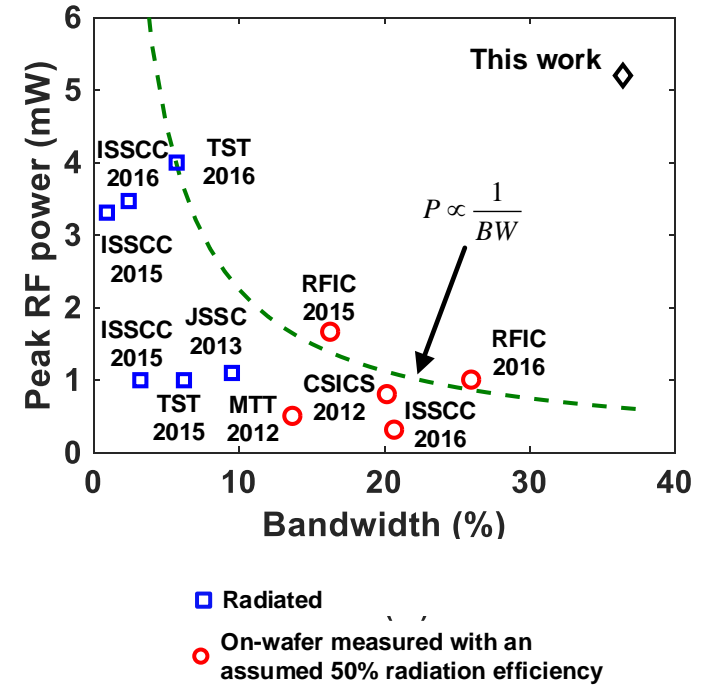
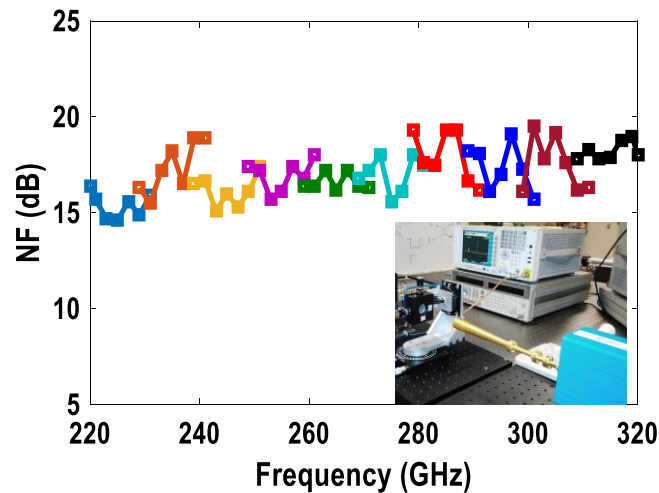
Antenna Pattern of One Line (265GHz)

Experimental Results

Effective Isotropically-Radiated Power

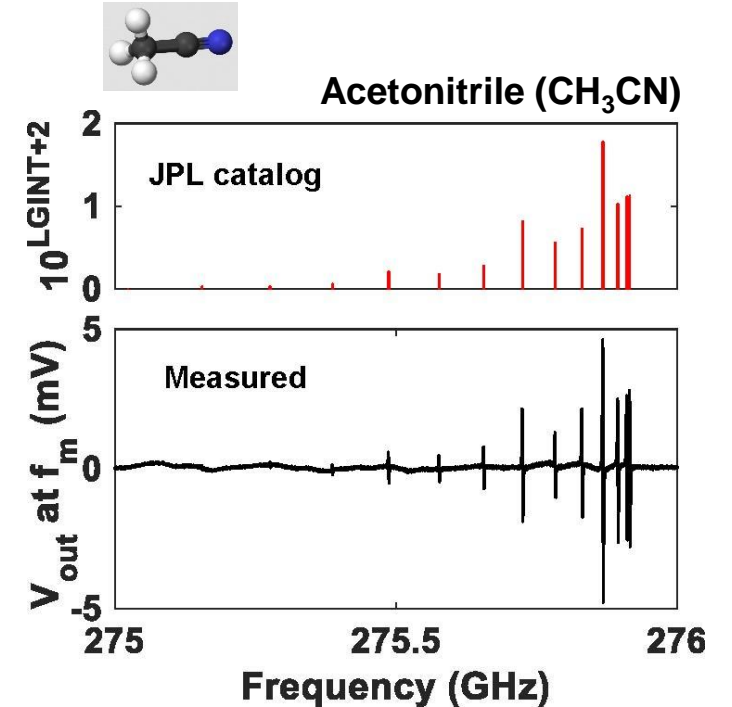
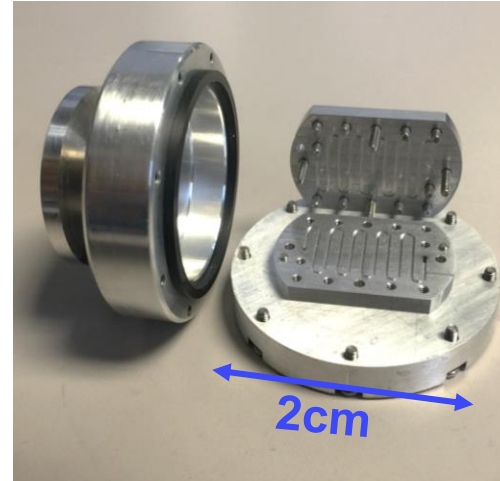
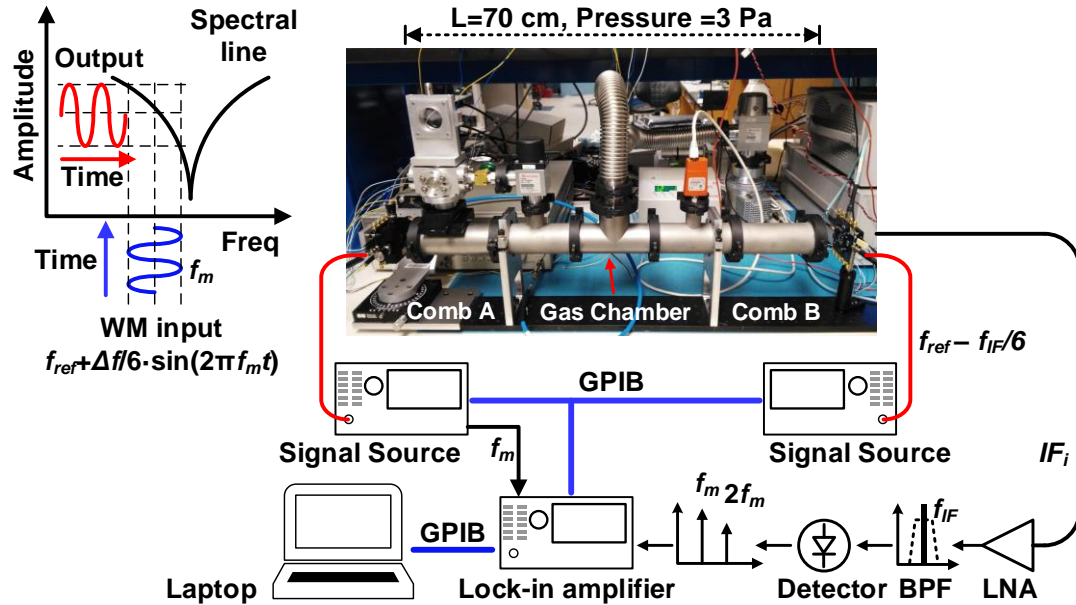


Noise Figure of Each Channel (SSB, Antenna Loss Included)



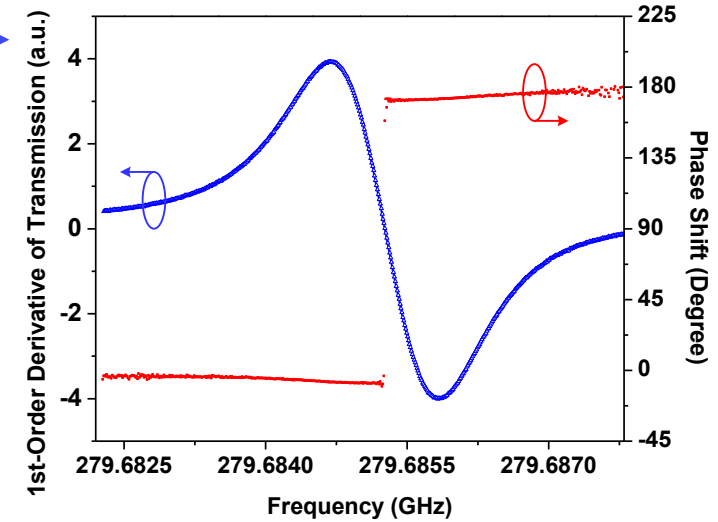
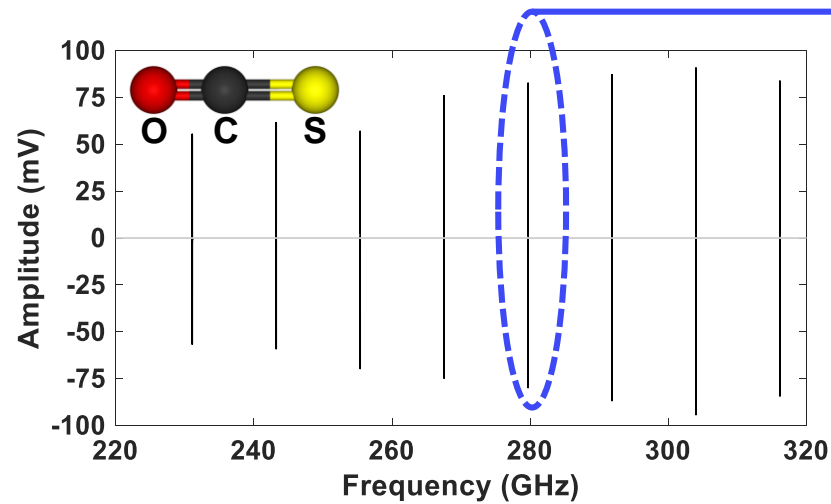
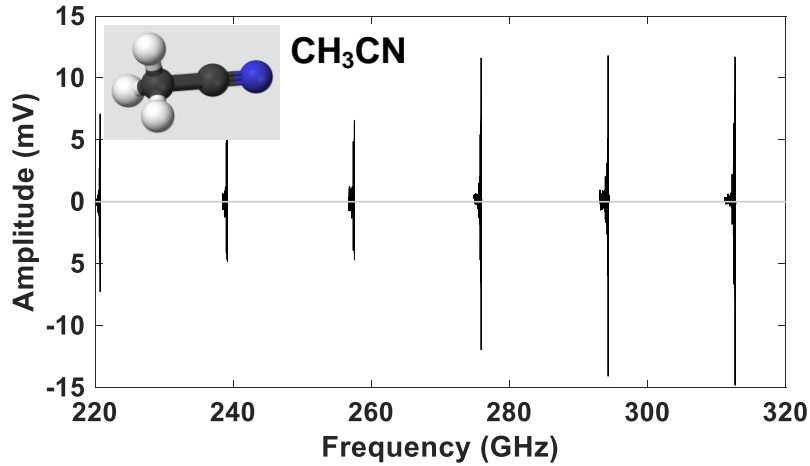
- Total radiated power of the 10 comb lines: 5.2 mW
 - Highest in silicon
- Minimum detectable signal: 0.1 fW (-130 dBm) @ $\tau=1$ ms

Spectroscopy Demonstration

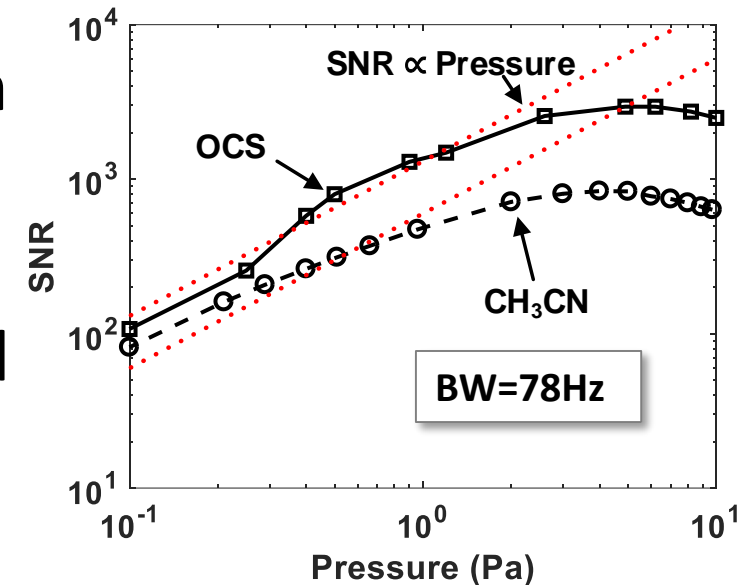


- Low pressure is applied to eliminate the spectral broadening due to the inter-molecular collisions
- Wavelength modulation is used to reduce the impacts of the standing wave inside the gas chamber

Spectroscopy Results



- Sensitivity: 11 ppm for OCS, 14 ppm for CH₃CN, 3 ppm for HCN...
 - 10-100 ppt with standard gas pre-concentration
- Any polar molecule heavier than HCN can be detected
- Spectral linewidth is ~ 1 MHz, leading to absolute specificity



Conclusions

- Using CMOS/BiCMOS device technologies not only enables “THz frontend + analog/digital baseband” integration, but may also directly enhance the THz-circuit performance
 - Homogeneous arrays: high-density coherent wave interference
 - Large total radiated power
 - Ultra-narrow beam generation
 - Heterogeneous arrays: high-parallelism EM spectral sensing
 - Broadband coverage
 - Optimal energy efficiency
- Key technology: versatile THz circuits with multi-functional structures

A unified design framework:
device, circuit, electromagnetism and architecture, all rolled into one

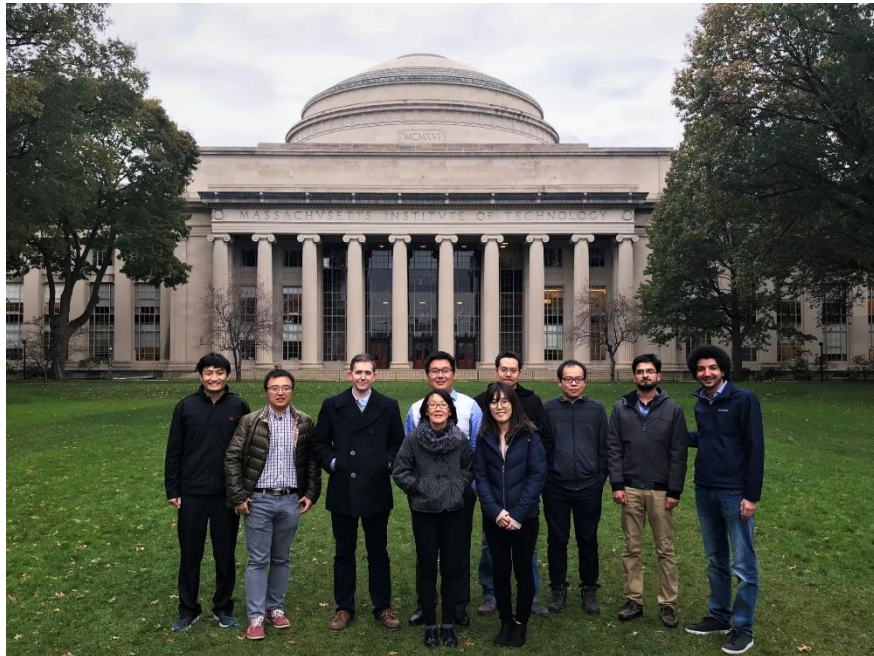
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Large-Scale Terahertz Active Arrays in Silicon Using Highly-Versatile Electromagnetic Structures

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